

# Run-In Behaviors of Solid Lubricants



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Lehigh University  
Bethlehem, PA



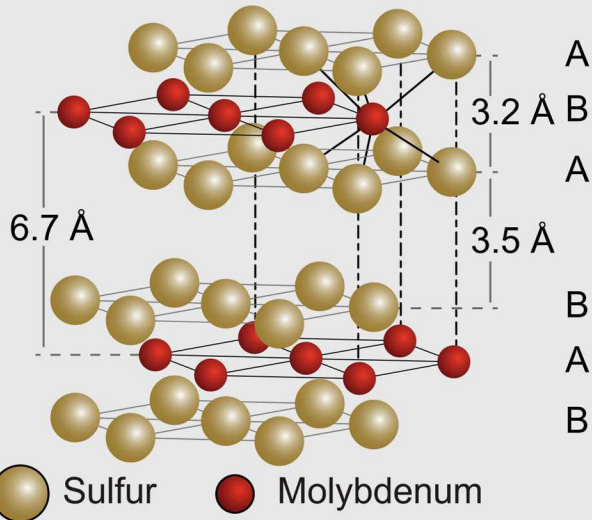
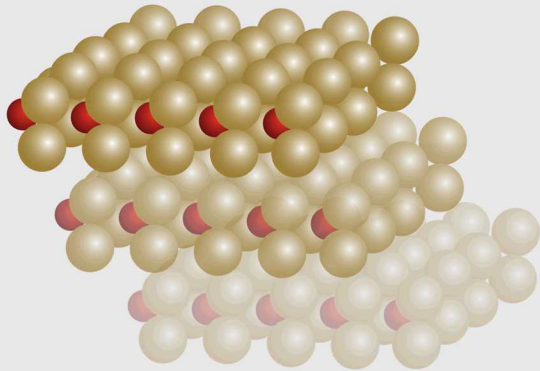
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# MoS<sub>2</sub> – How it Works

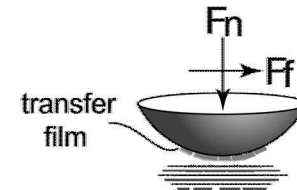
## molybdenum disulphide

$\mu = 0.02 - 0.06$  (inert @ 1N)

$\mu = 0.15 - 0.25$  (humid air @ 1N)

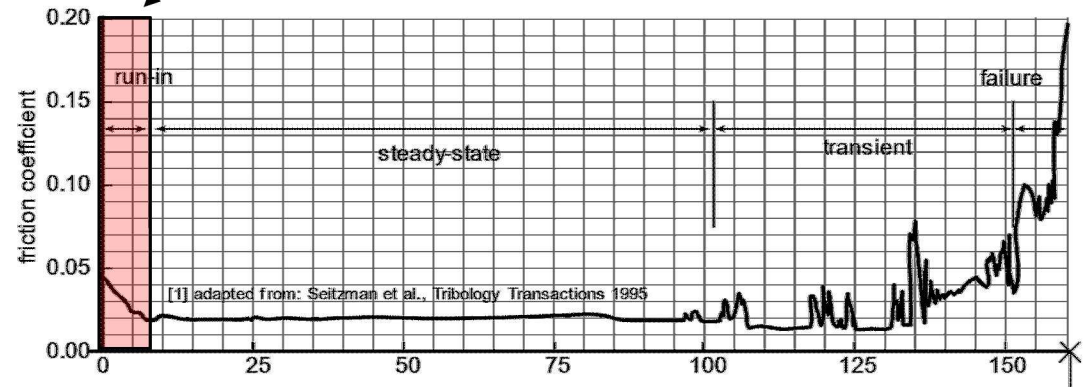
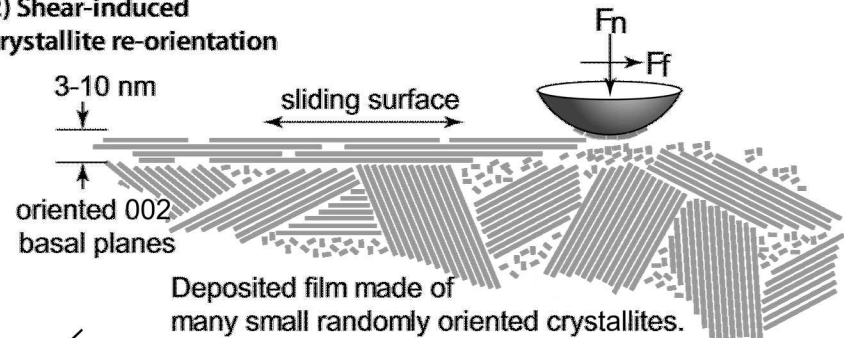


## generalized run-in processes



1) Transfer Film Formation

## 2) Shear-induced crystallite re-orientation



Typical friction trace for MoS<sub>2</sub> lubricated contact. Initial run-in is followed by steady state low friction which ultimately transitions to high friction before failure [1]

## Motivation – Environmental Sensitivity & Aging

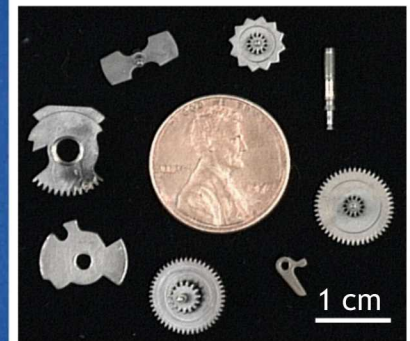
### Space:

- operate in vacuum (+atomic oxygen in low earth orbit)
- store months – years before use; generally non-serviceable
- operating temperatures from 50 – 300K, depending on location
- large investments of time and money

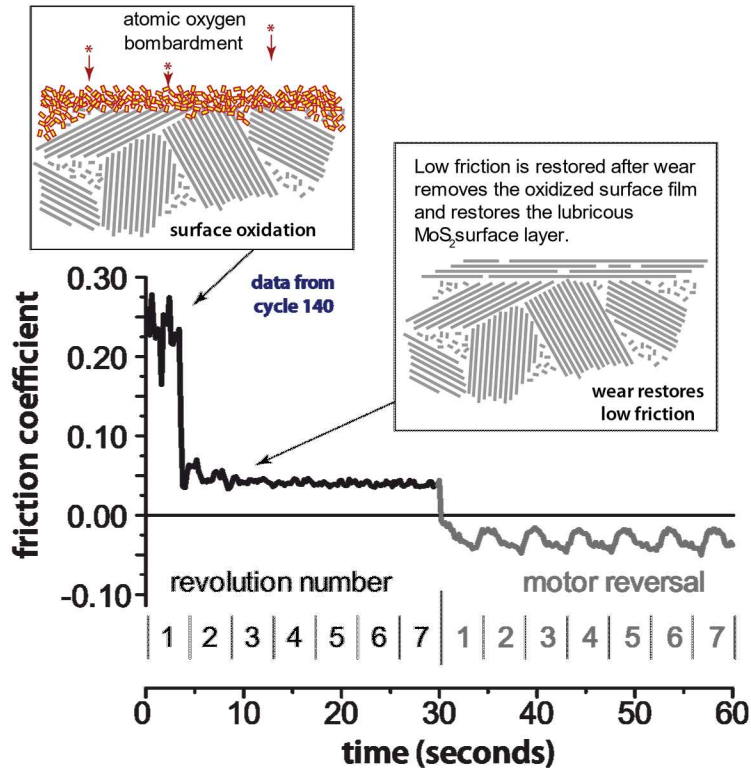


### Precision Mechanisms:

- inert gas near  $P_{\text{atm}}$ , trace  $\text{O}_2$ ,  $\text{H}_2\text{O}$ , outgassing species
- store for decades; non-serviceable
- operating temperatures 200 – 350K
- large investments of time and money
- consequences (political, societal) of failure are unacceptable



## Bad Actors – Environment & Aging

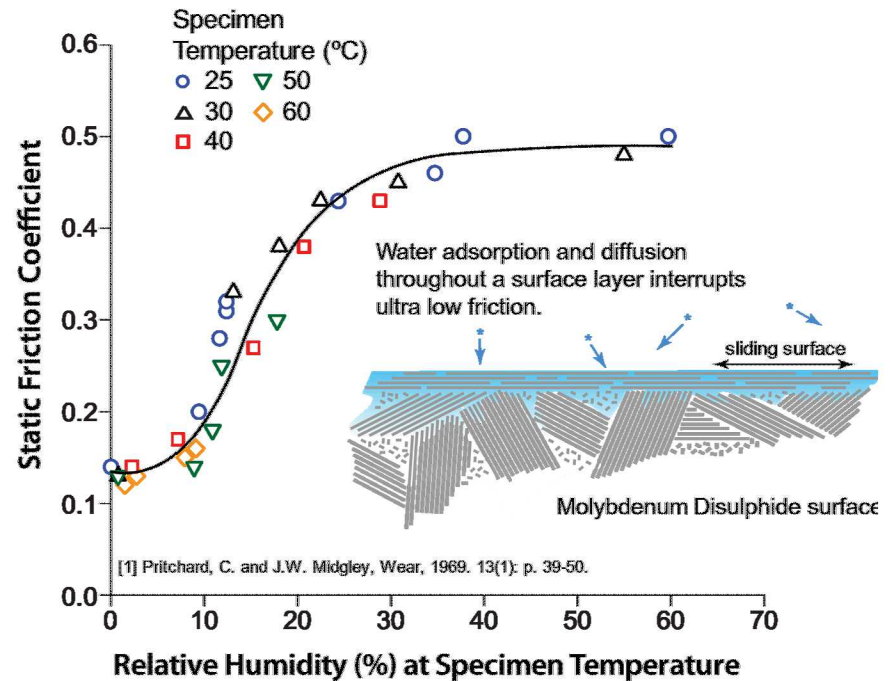
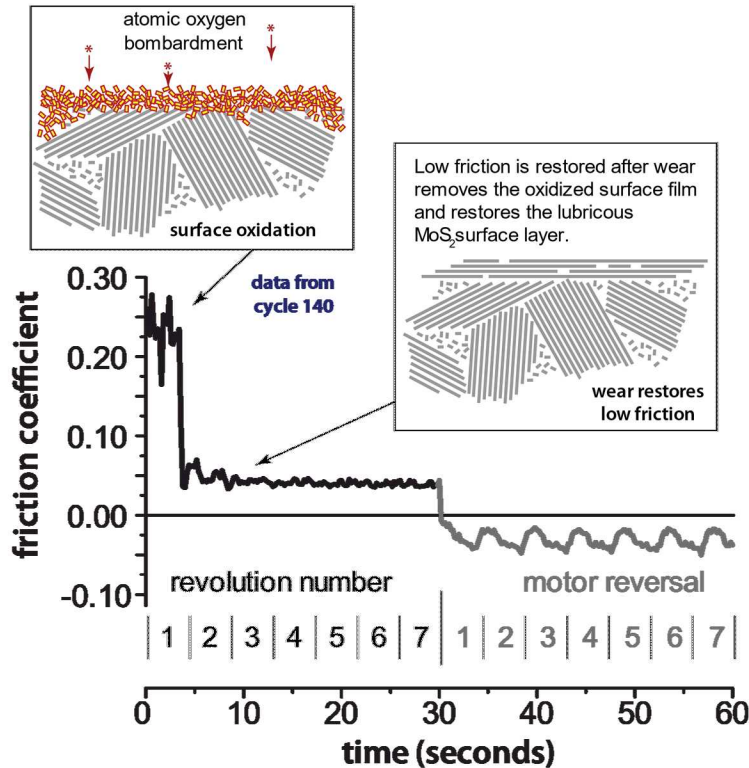


Krick et. al, unpublished

- Oxidation can occur in space (AO - fast), air at high temps (O<sub>2</sub> – fast) and room temp (H<sub>2</sub>O – slow)

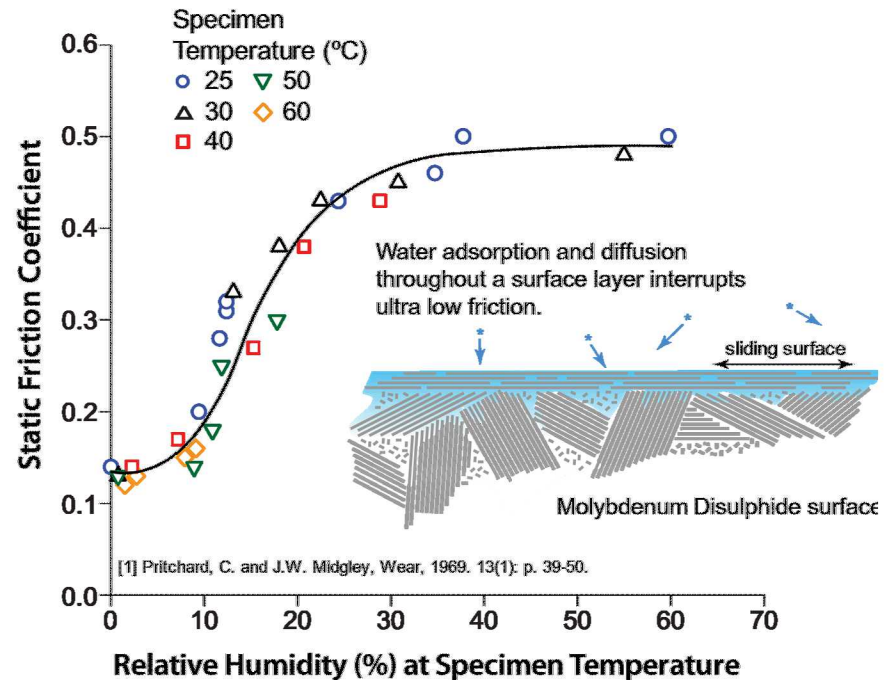
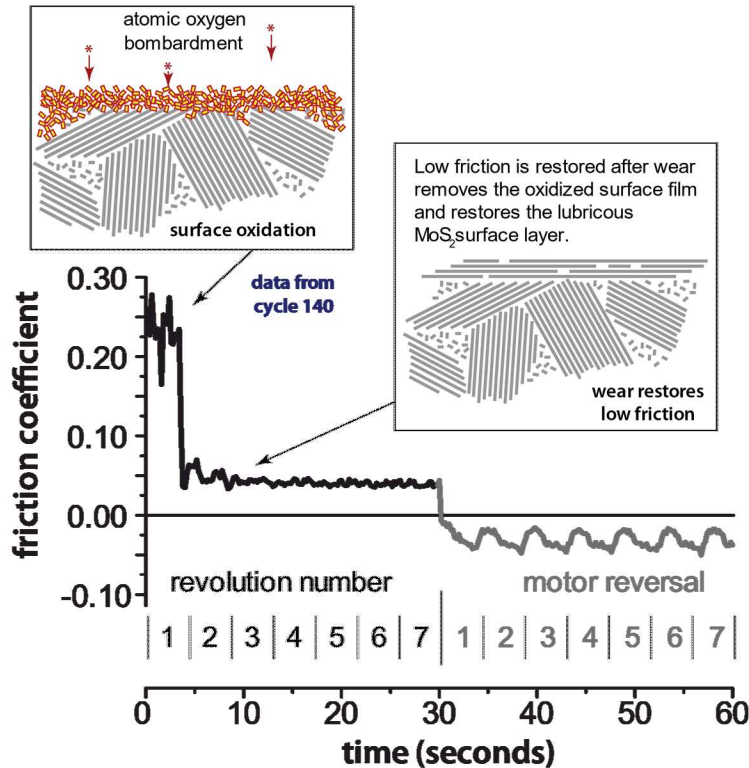


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- Water enhances static and kinetic friction behaviors via increased shear between layers

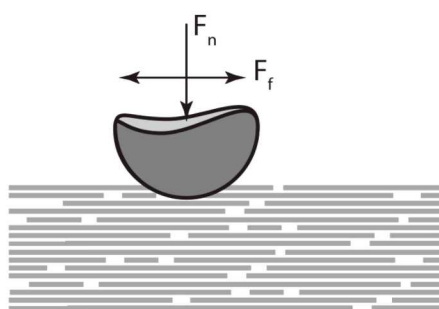
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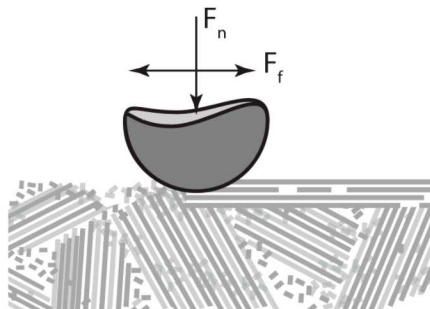
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Many components operate infrequently and for very few cycles – *effectively living in the run-in regime*

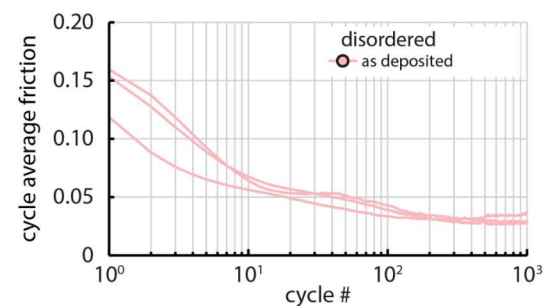
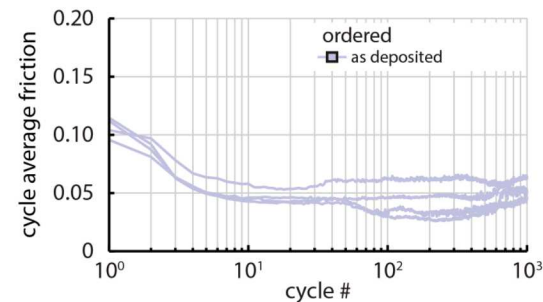
## Co-Influencing Factors: Microstructure & Oxidation



Ordered films

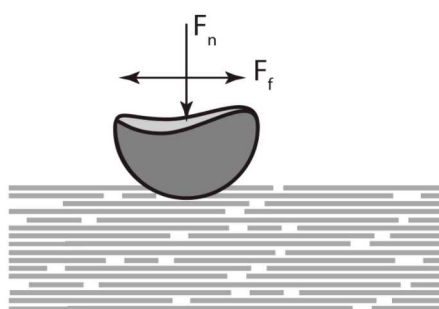


Disordered films

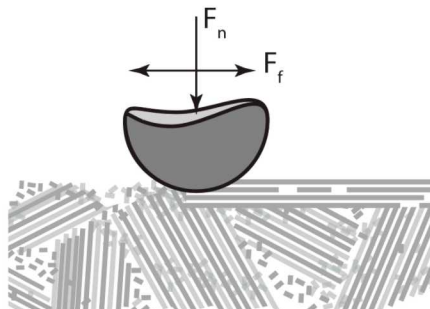


- Basally oriented or burnished (ordered) films lessen need of reorientation, reducing friction

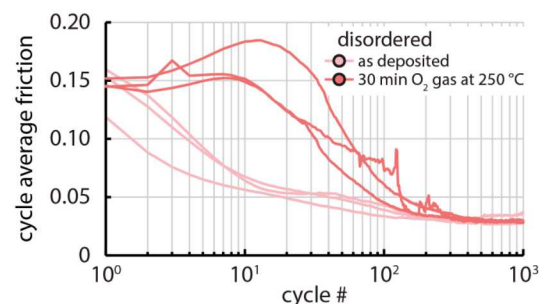
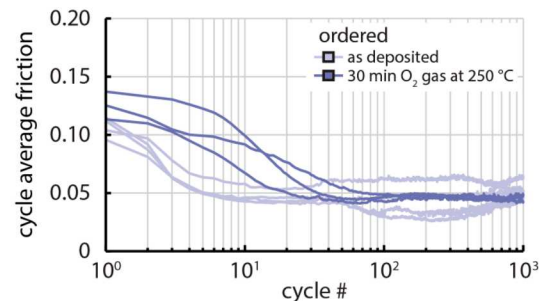
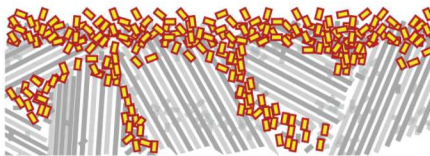
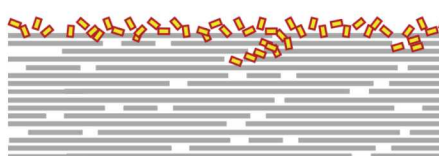
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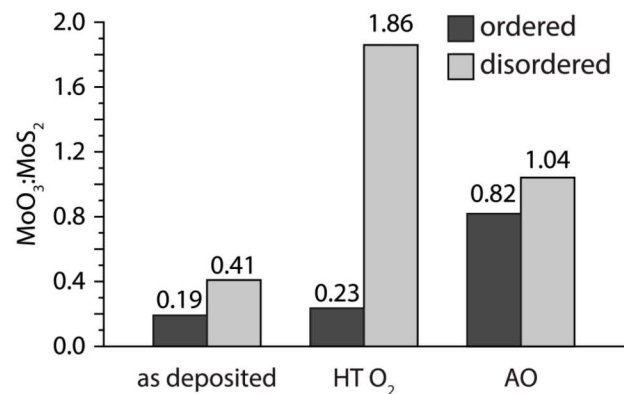


Disordered films



- Basally oriented or burnished (ordered) films lessen need of reorientation, reducing friction
- Also reduces edge:basal surface ratio, reducing run-in effects from oxidation
- Problem solved!

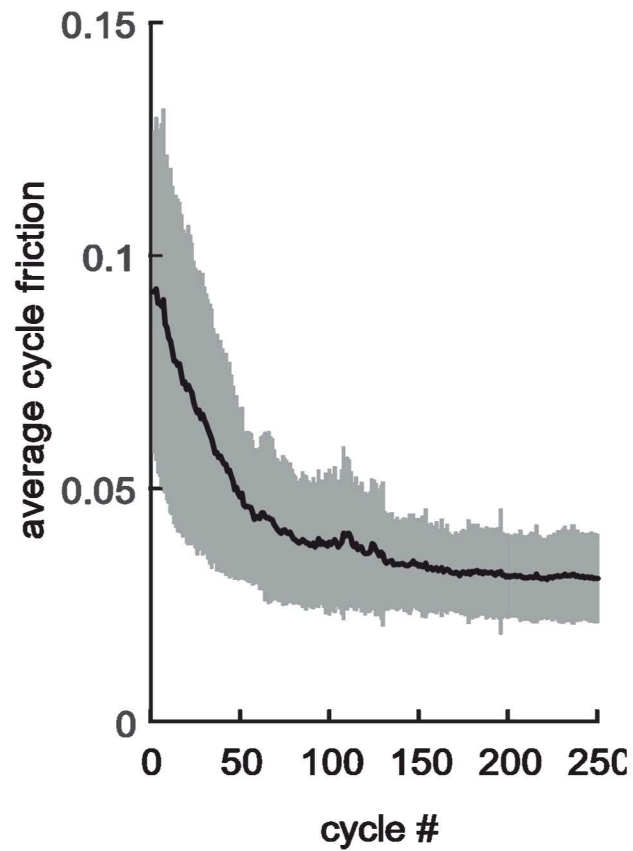
Mo 3p signal - MoO<sub>3</sub>:MoS<sub>2</sub> ratio





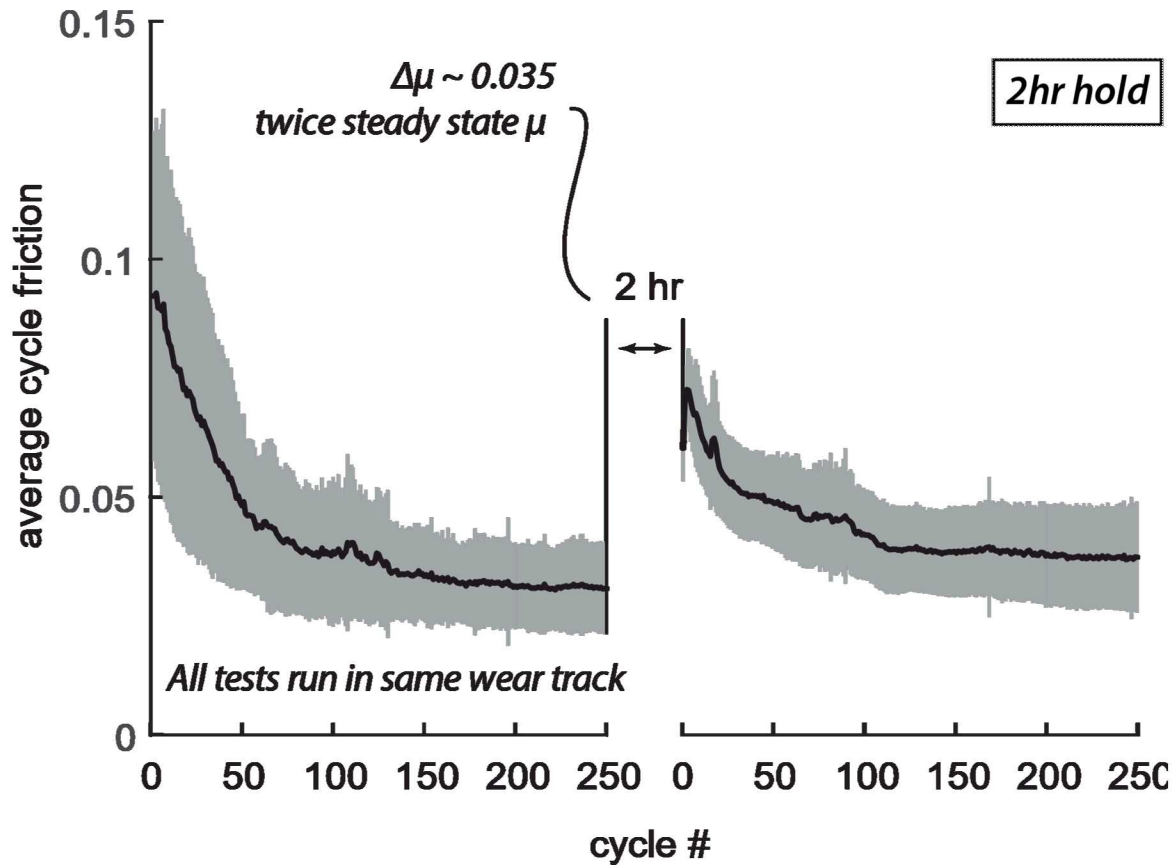
## 9 Run-In Solves Everything

- Recipe for success: run film in to steady state



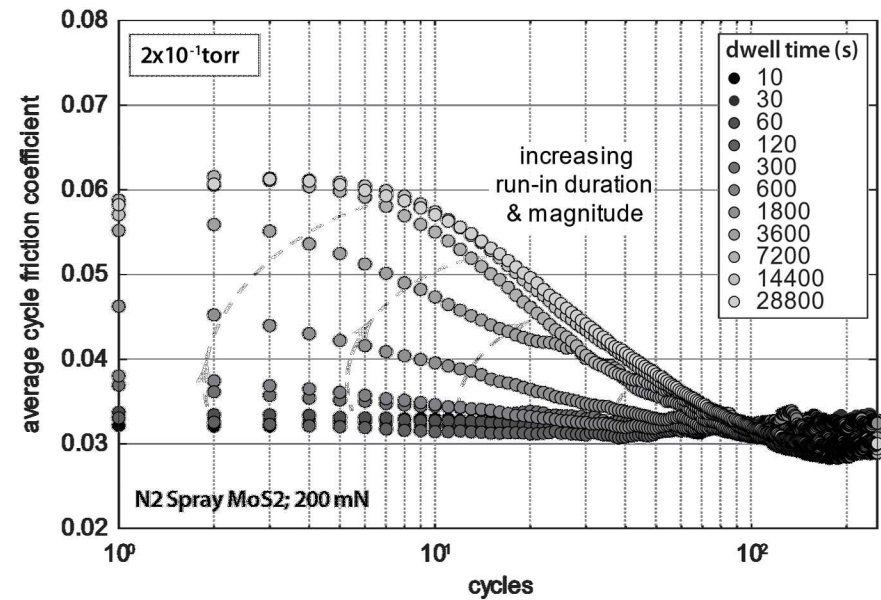
## Run-In Solves Everything... Except Time...

- Recipe for success: run film in to steady state... and watch friction increase upon return



## Re-Run-In Time Matters

- Increase in initial friction is monotonic, depending on time in between; run-in duration also affected
- This “stop-time” effect is observable in vacuum



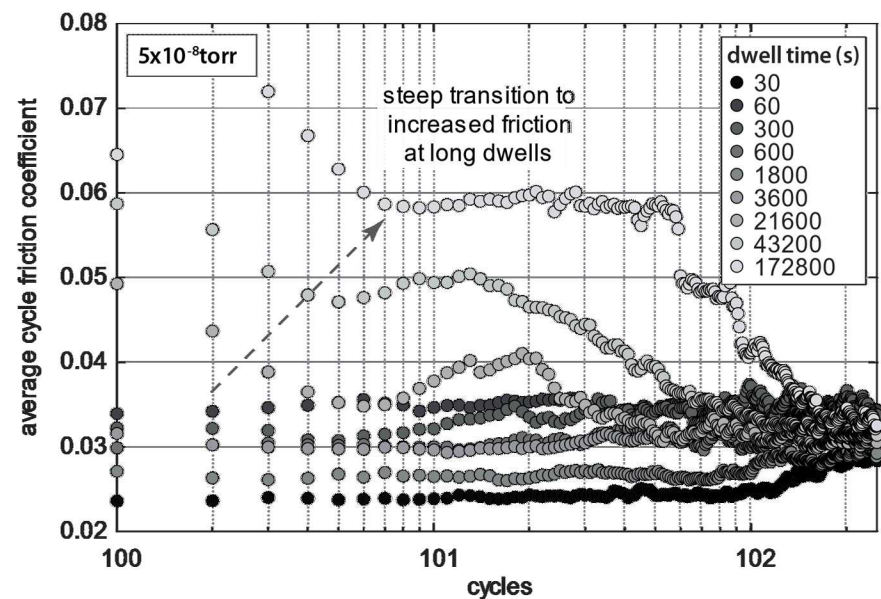
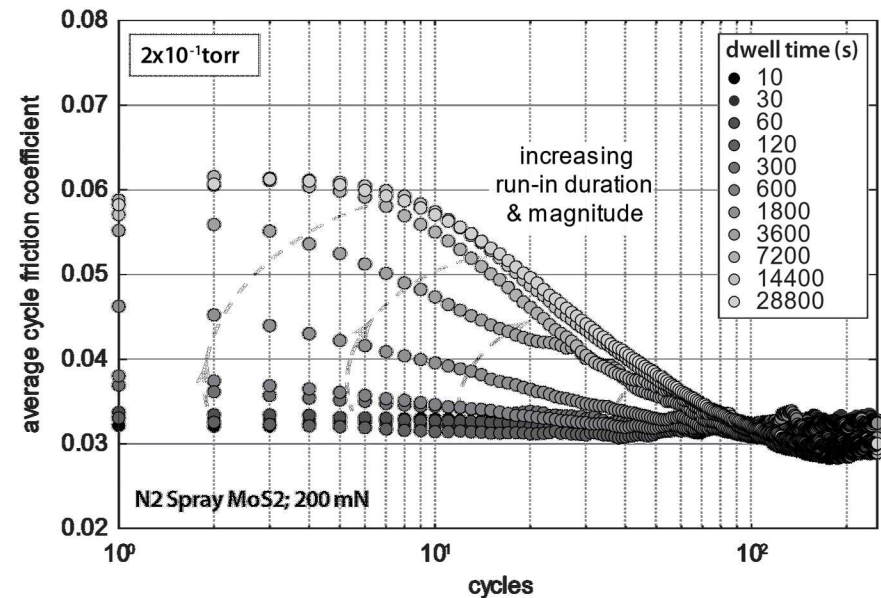
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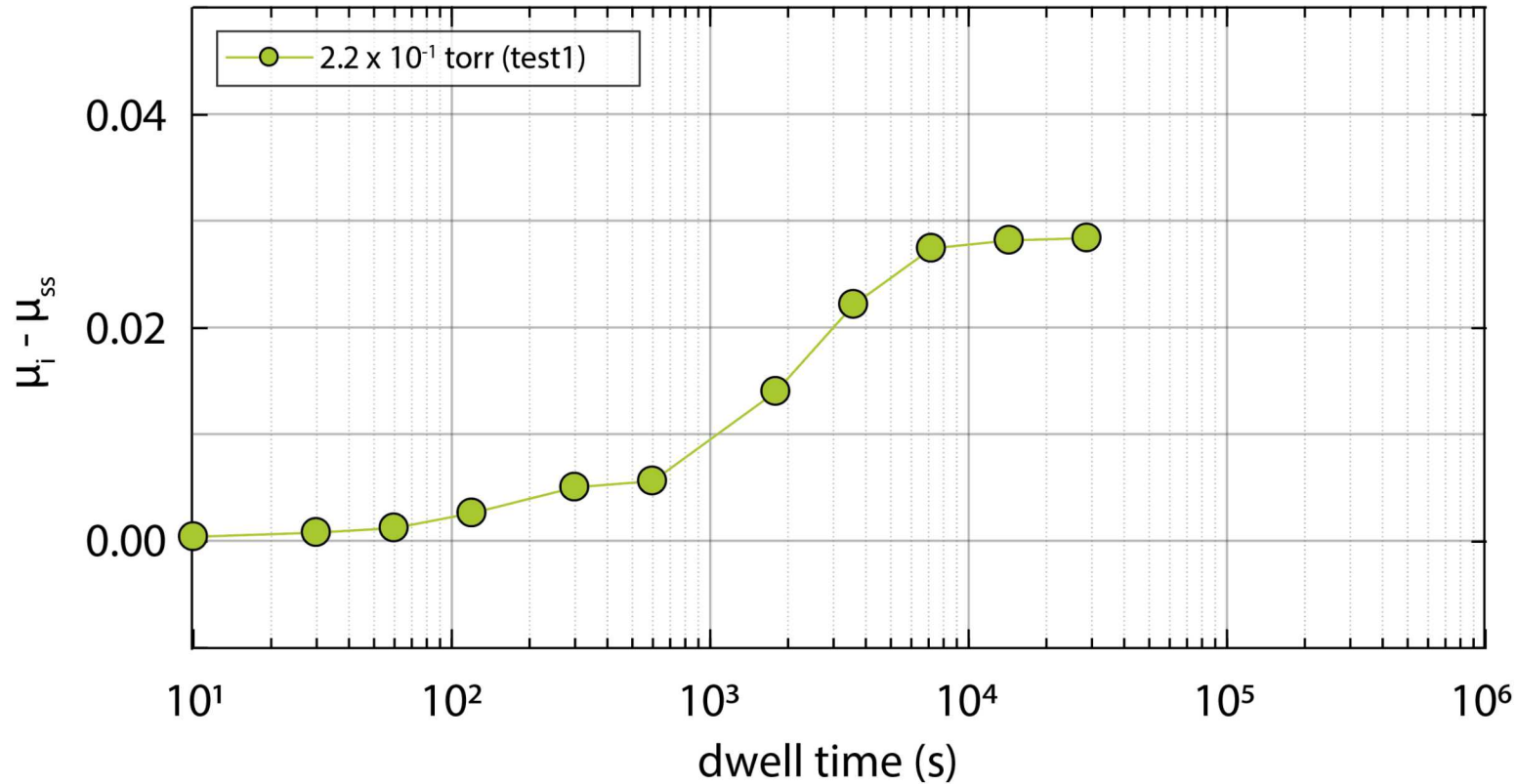
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- Higher vacuum levels also exhibit this behavior; more abrupt transition at longer dwell times

- Run-in is longer and has a consistently different shape, along with steady state variation at high vacuum

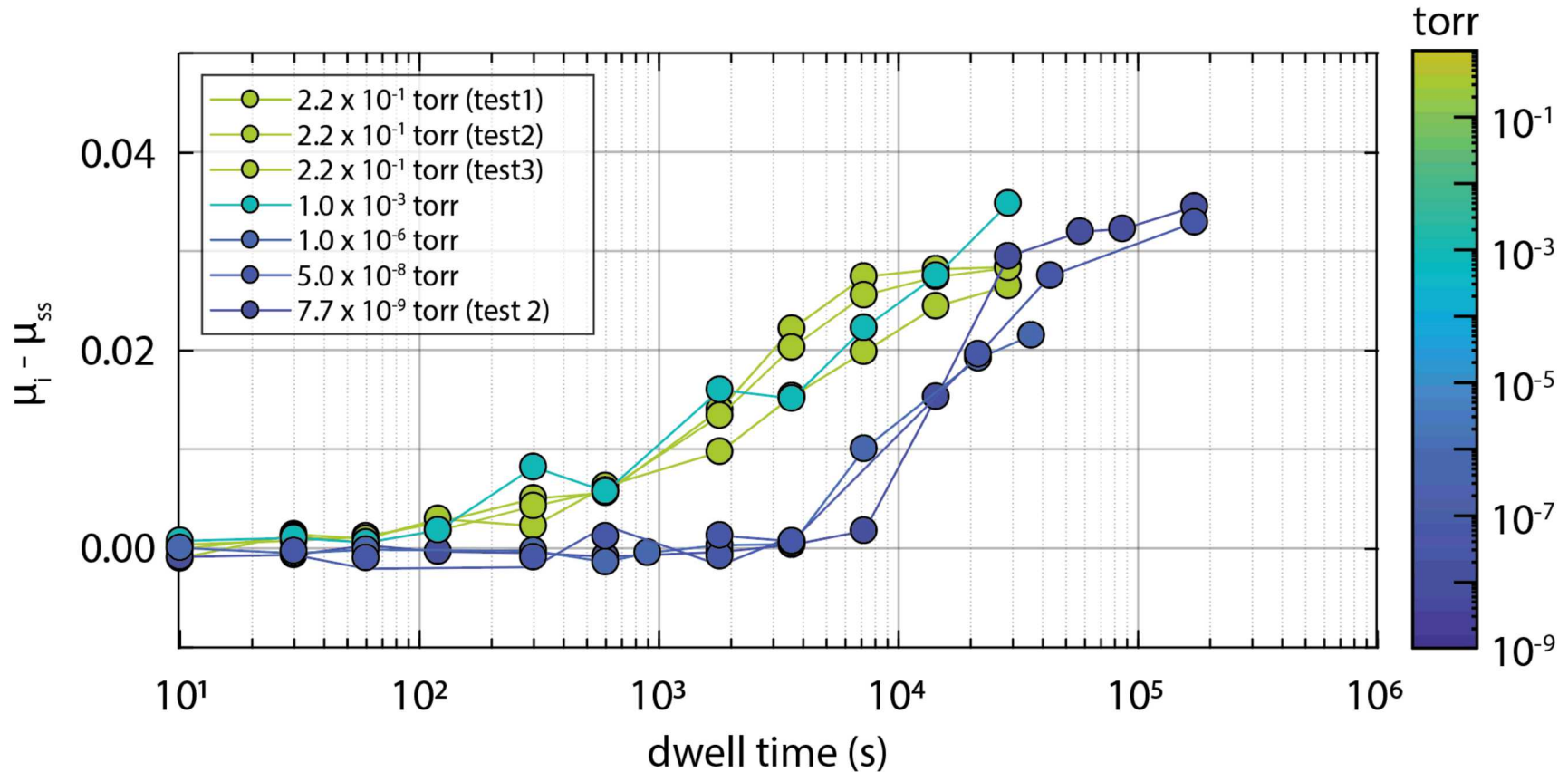






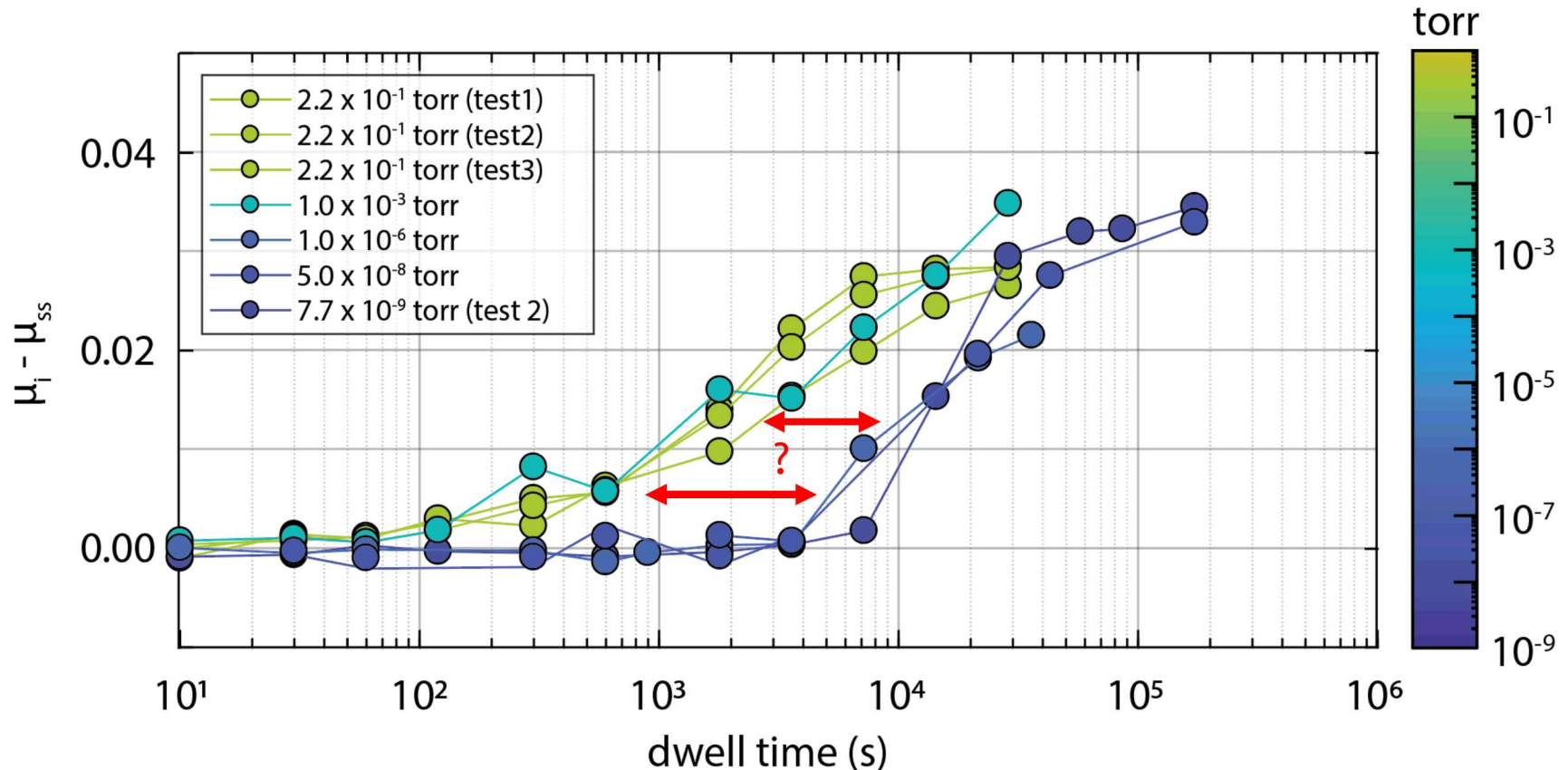
- View data as deltas - can plot the difference between previous steady state and returning initial friction

## Re-Run-In Pressure Matters too!



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- Observe stop time across a range of pressures, from  $2 \times 10^{-1}$  to  $7 \times 10^{-9}$  torr

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- Observe stop time across a range of pressures, from  $2 \times 10^{-1}$  to  $7 \times 10^{-9}$  torr

- Low and high pressures exhibit distinct behaviors over 2-3 orders of magnitude... Friction traces also distinct... suggests different mechanisms responsible

## What's Happening: Competing Mechanisms of Re-Run-In

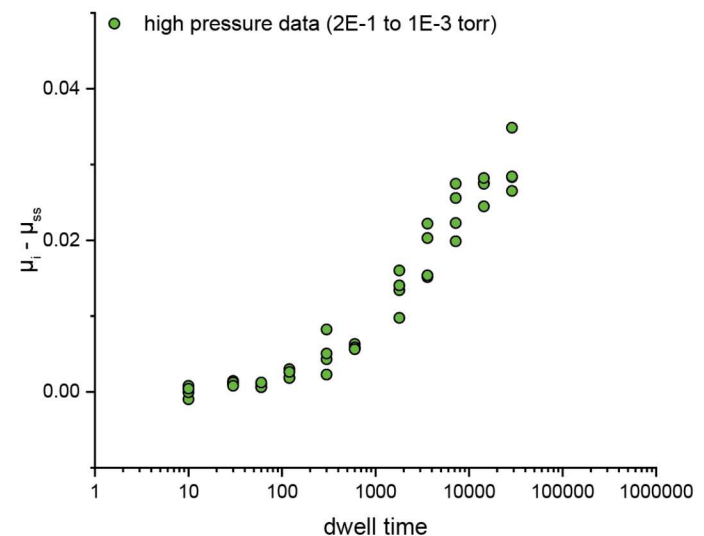
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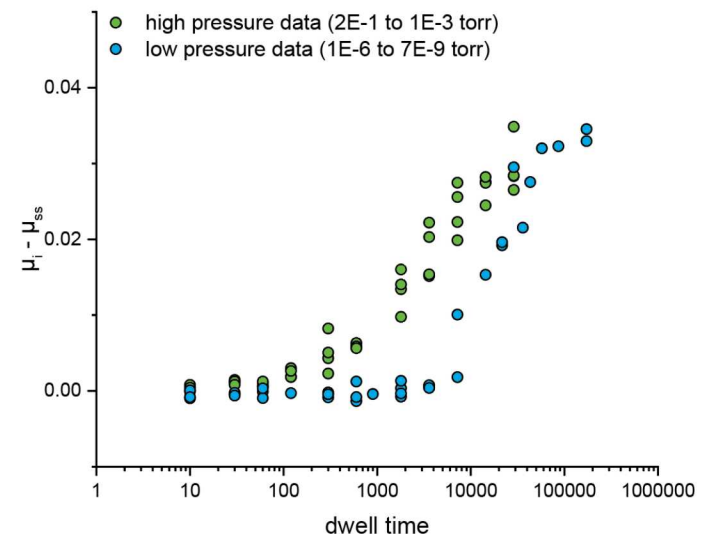
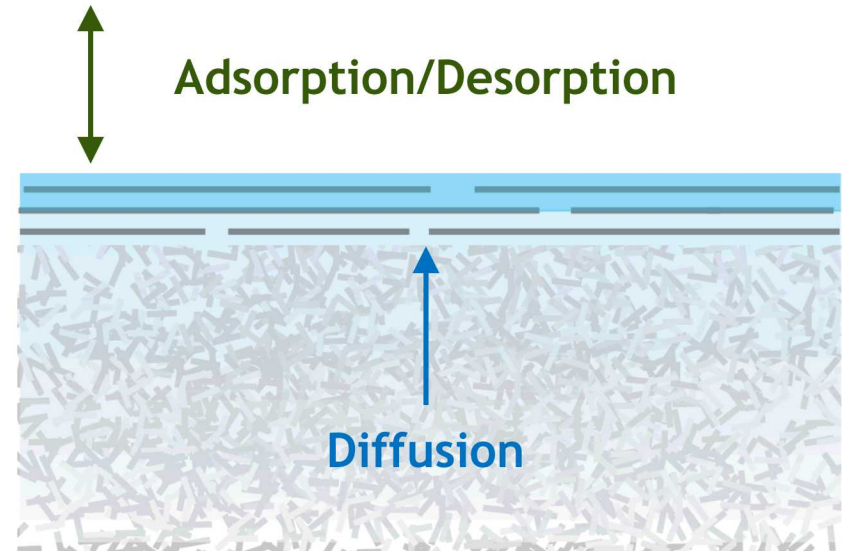
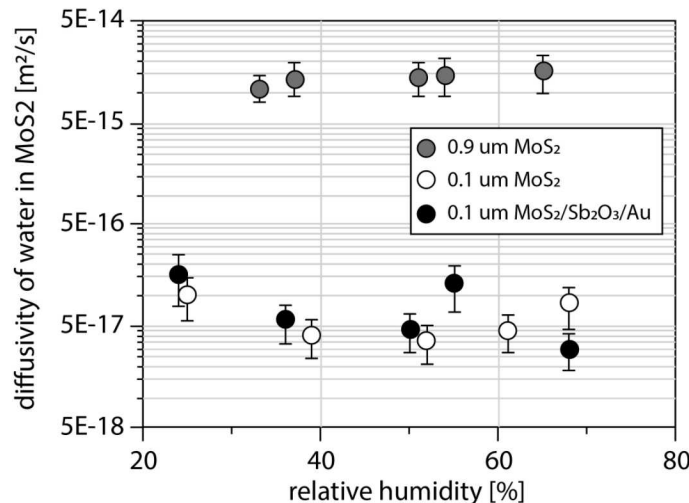
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- **Obvious Theory:** Concentration gradient of contaminants at surface & through bulk affecting friction

- Have observed adsorption isotherms for MoS<sub>2</sub> in literature (Johnston & Moore 1964); Colbert also showed ability of MoS<sub>2</sub> films to take up water and diffusivity (Colbert 2012)



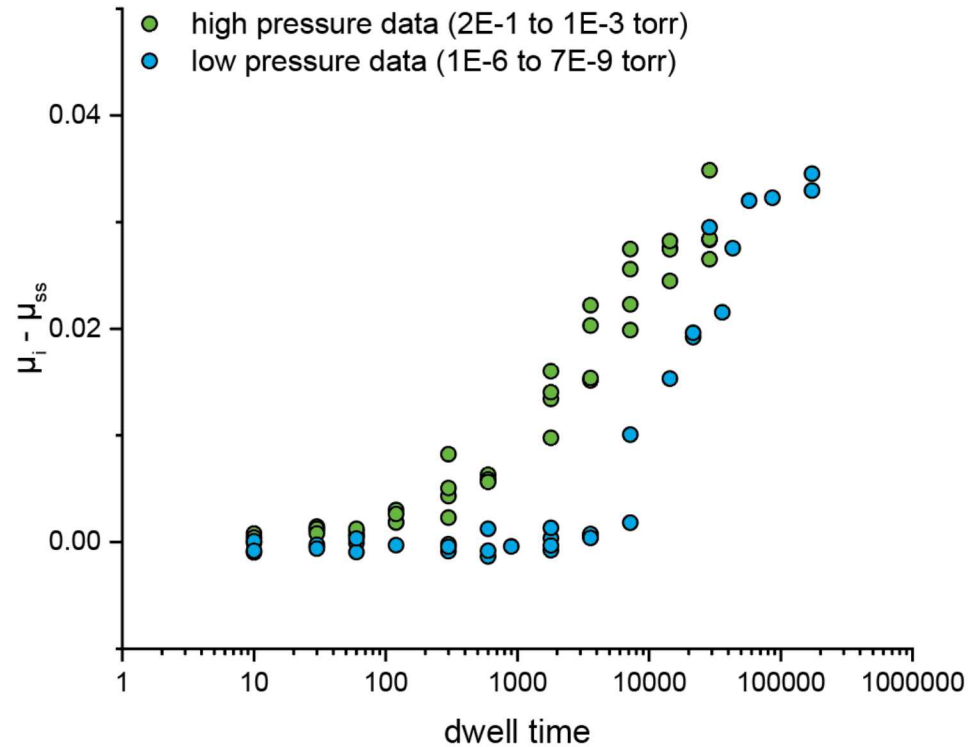
# Simple Coverage Model

$$\frac{d\theta}{dt} = k_s(1-\theta) = k_s - k_s\theta$$

$$\theta = 1 - \frac{1}{k_s} e^{-k_s t}$$

- Can simple fractional coverage model help?

- K & s help account for diffusion and sticking (adsorption)



# Simple Coverage Model

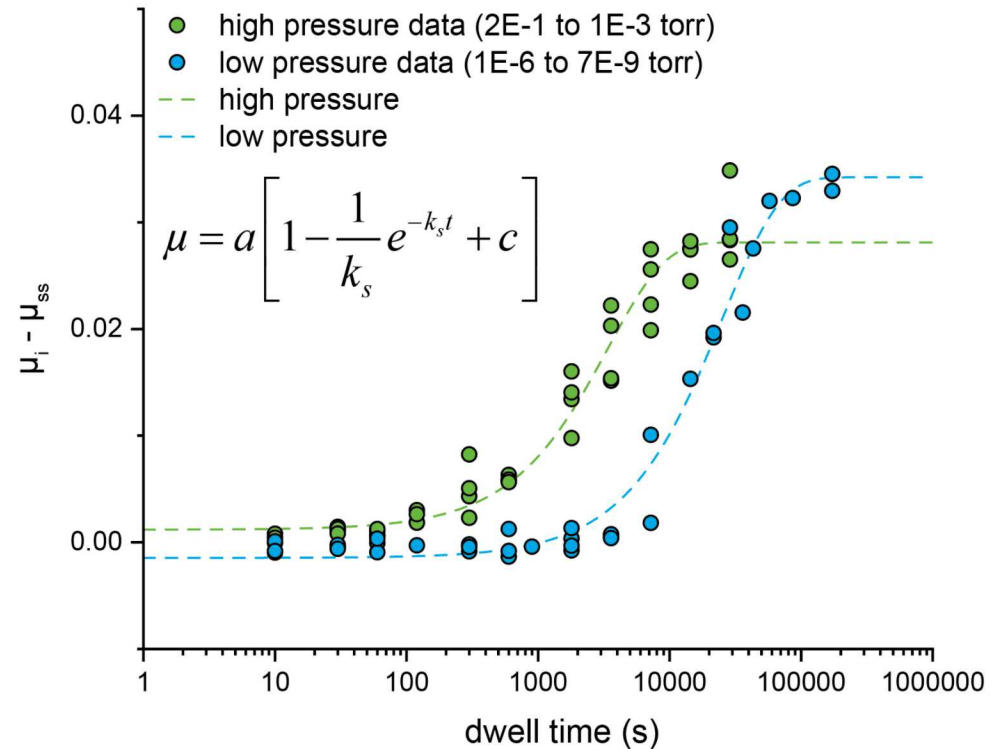
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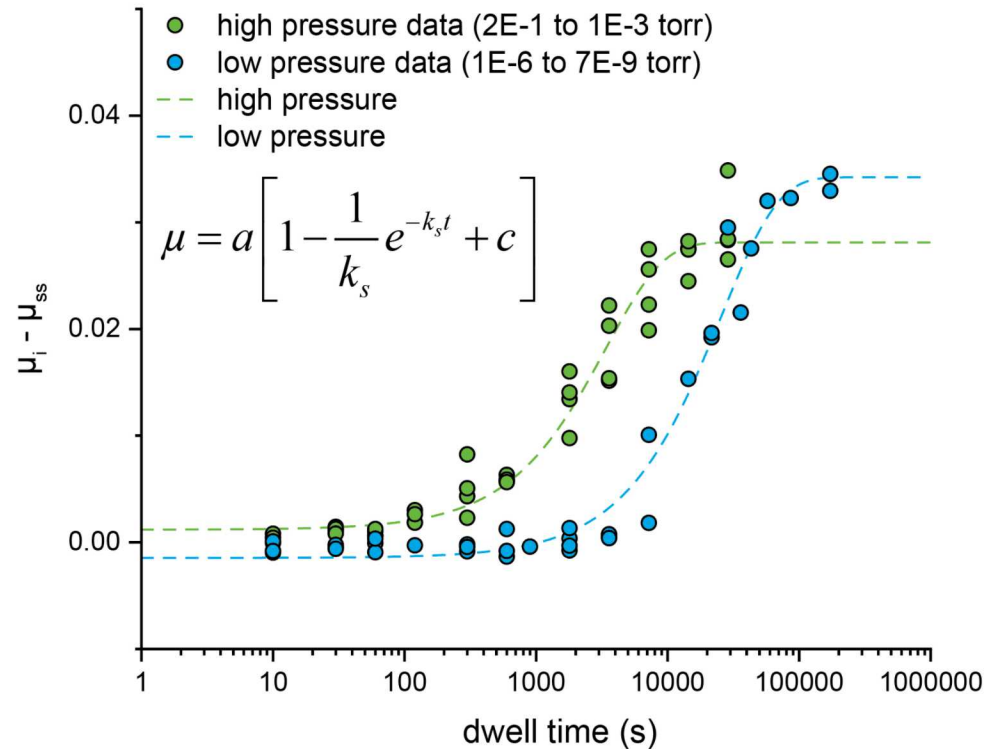
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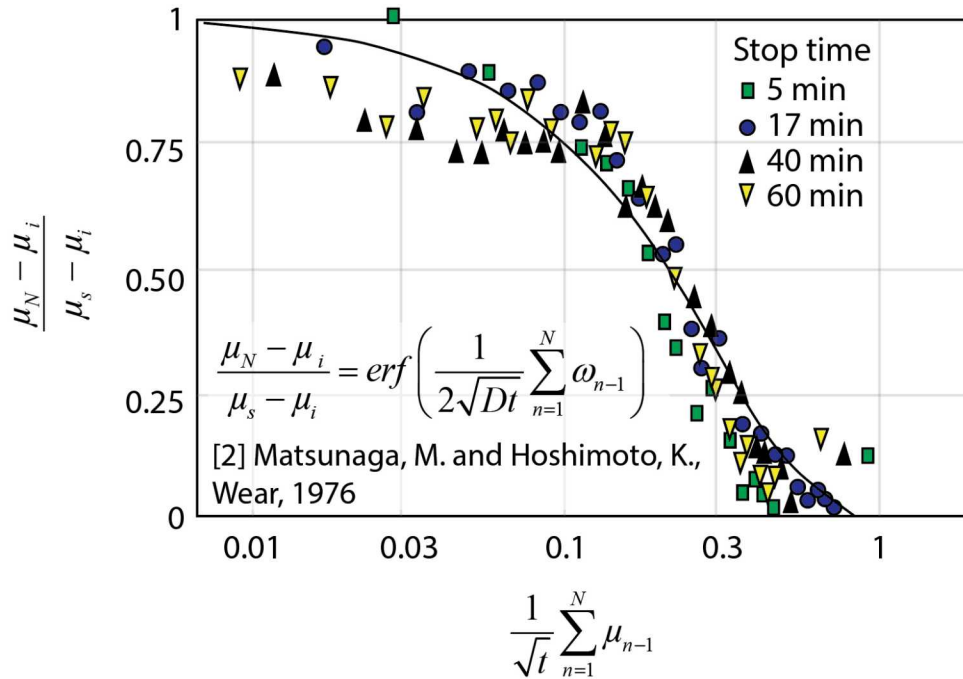
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- Adsorbate competition? Different sites?  
Vapor pressures?



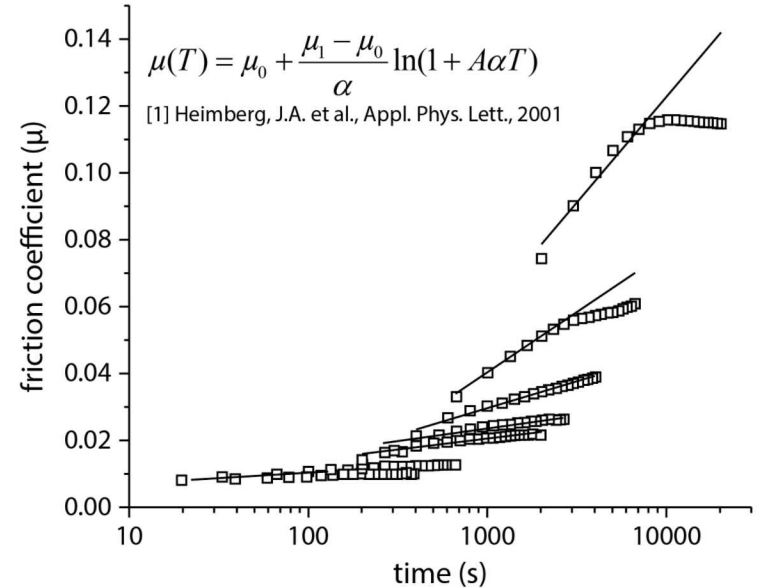
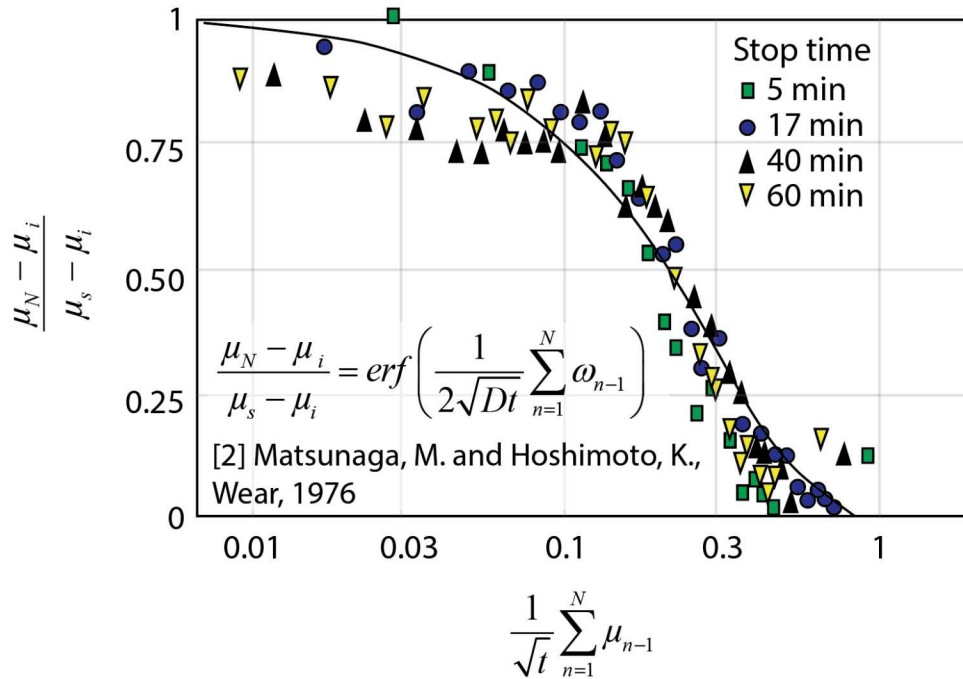
***“All models are wrong, but some are useful”***  
- George Box

## Not Alone: Re-Run-In Modeling in Literature



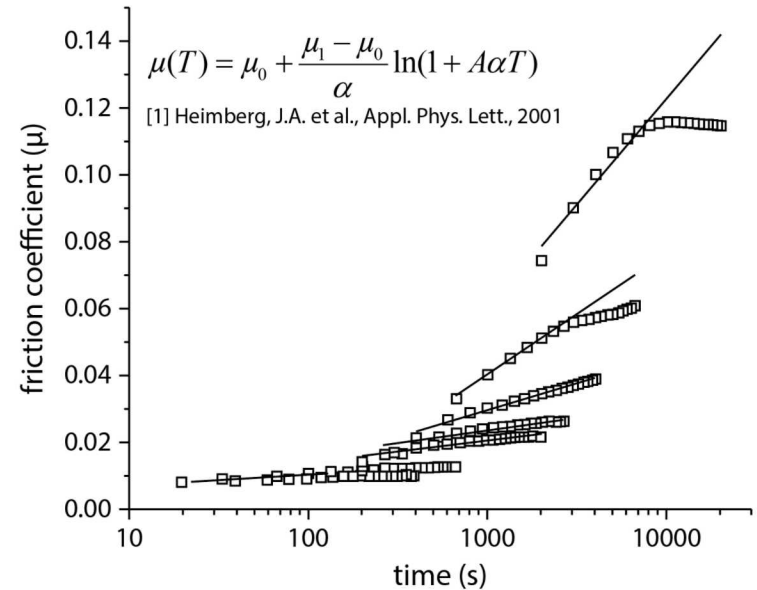
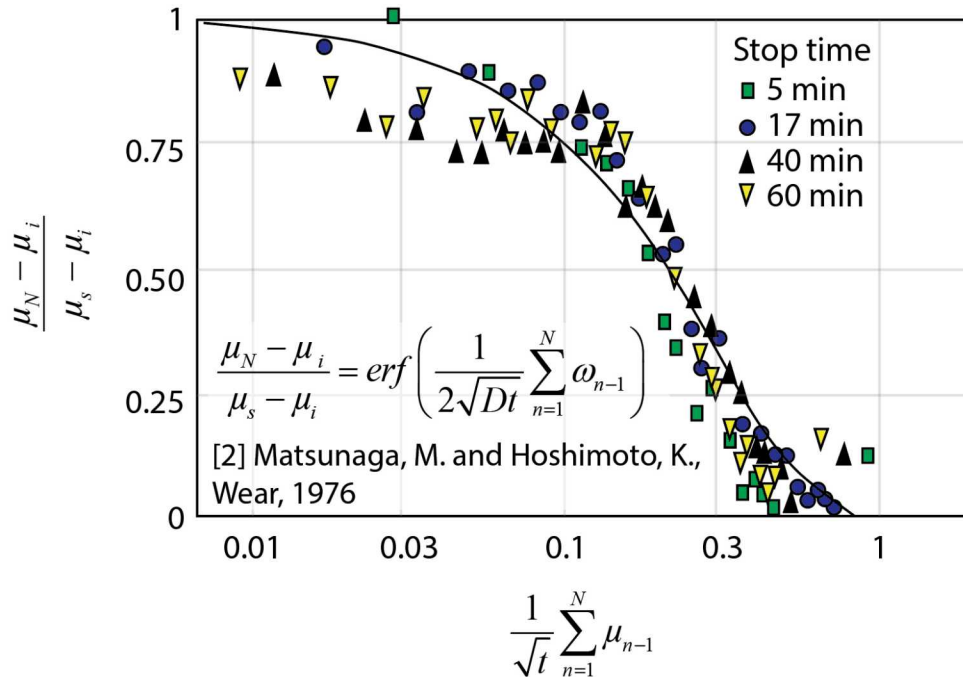
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  - Langmuir is pressure dependent, not time (maybe a kinetic model exists?)

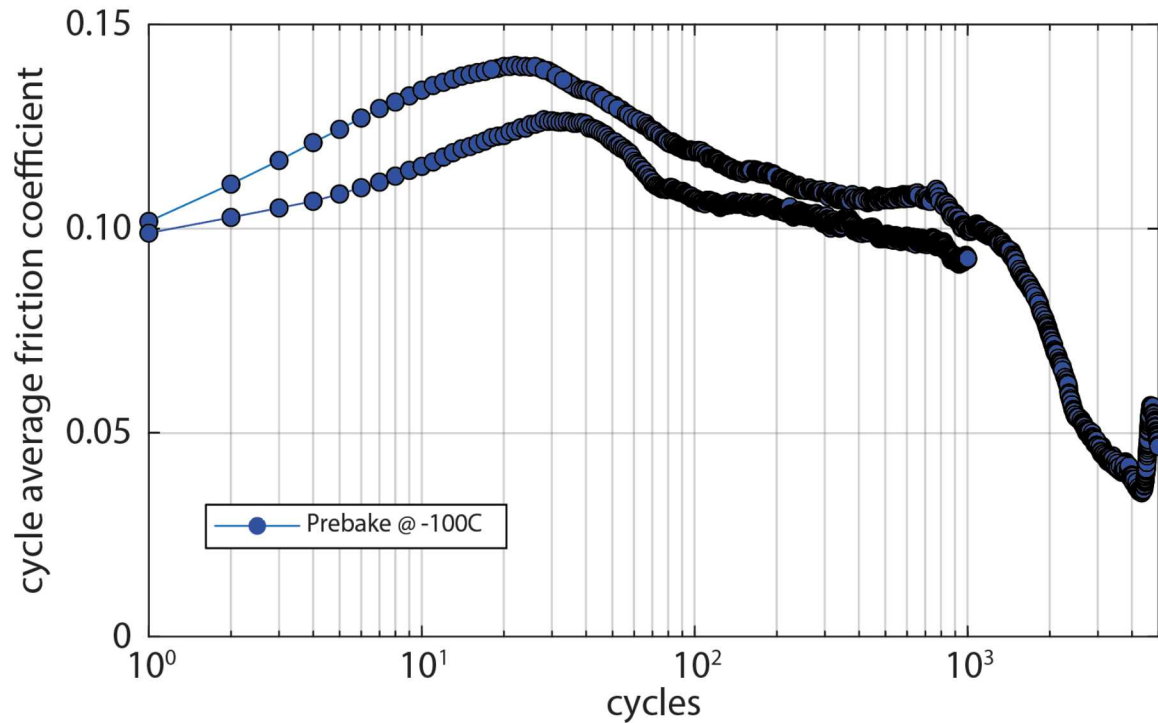
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**In all cases (two) either the interpretation/physics didn't match – or the fit didn't.**

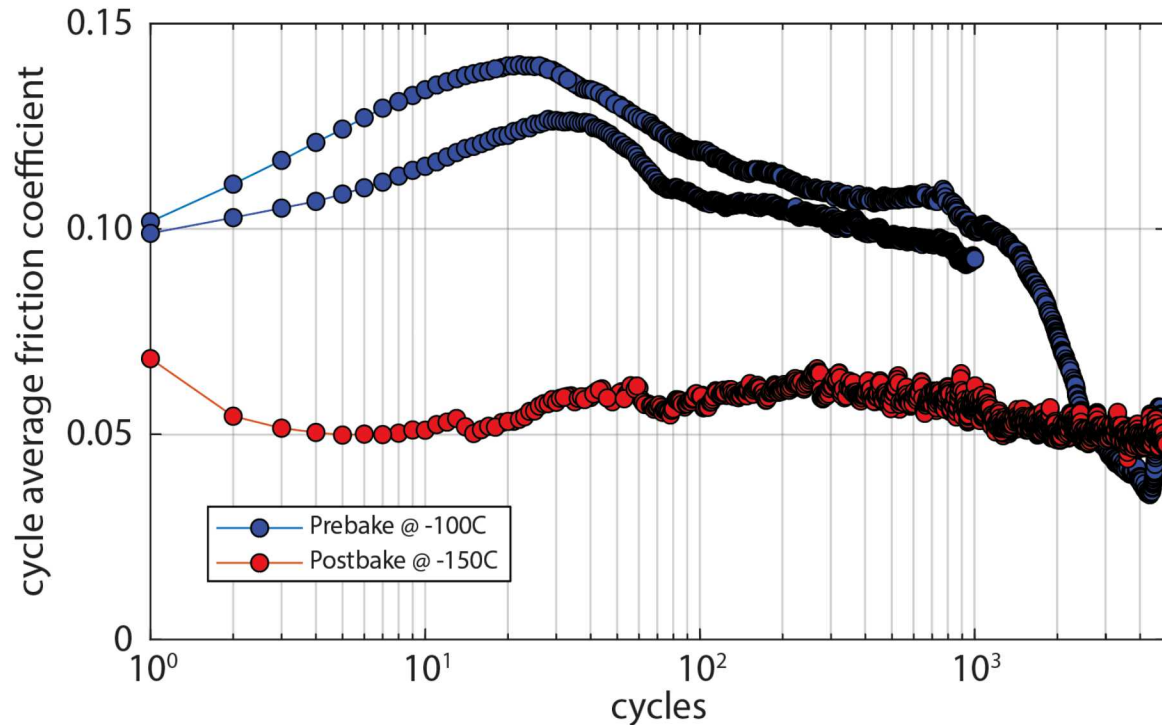
## Testing the Mechanism – Playing with Temperature



- At low temperature, likely ice or water retained in subsurface
- Noticed prolonged (5K cycle) run-in at -100 C (5E-9 torr) on samples prior to baking out

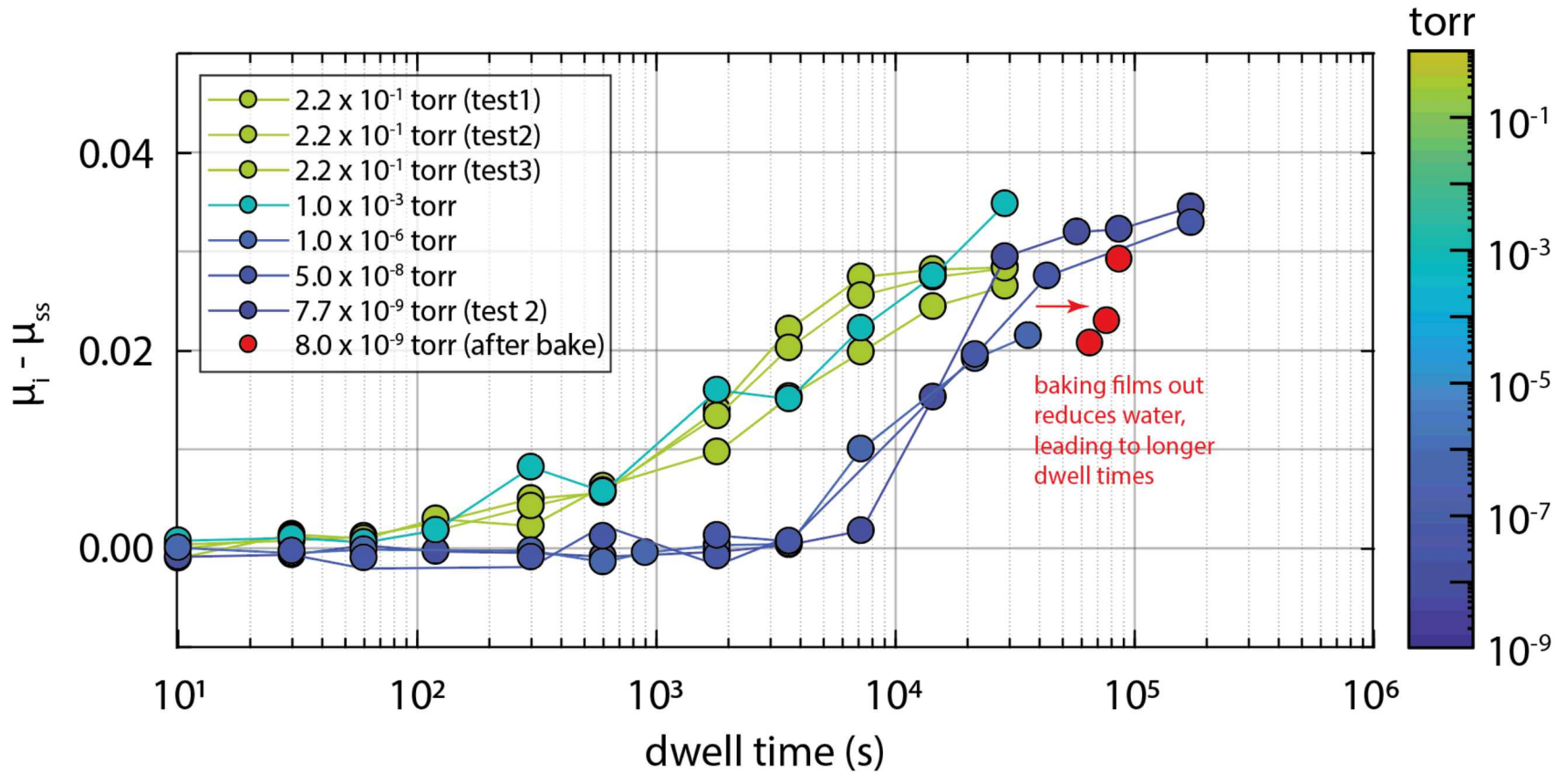


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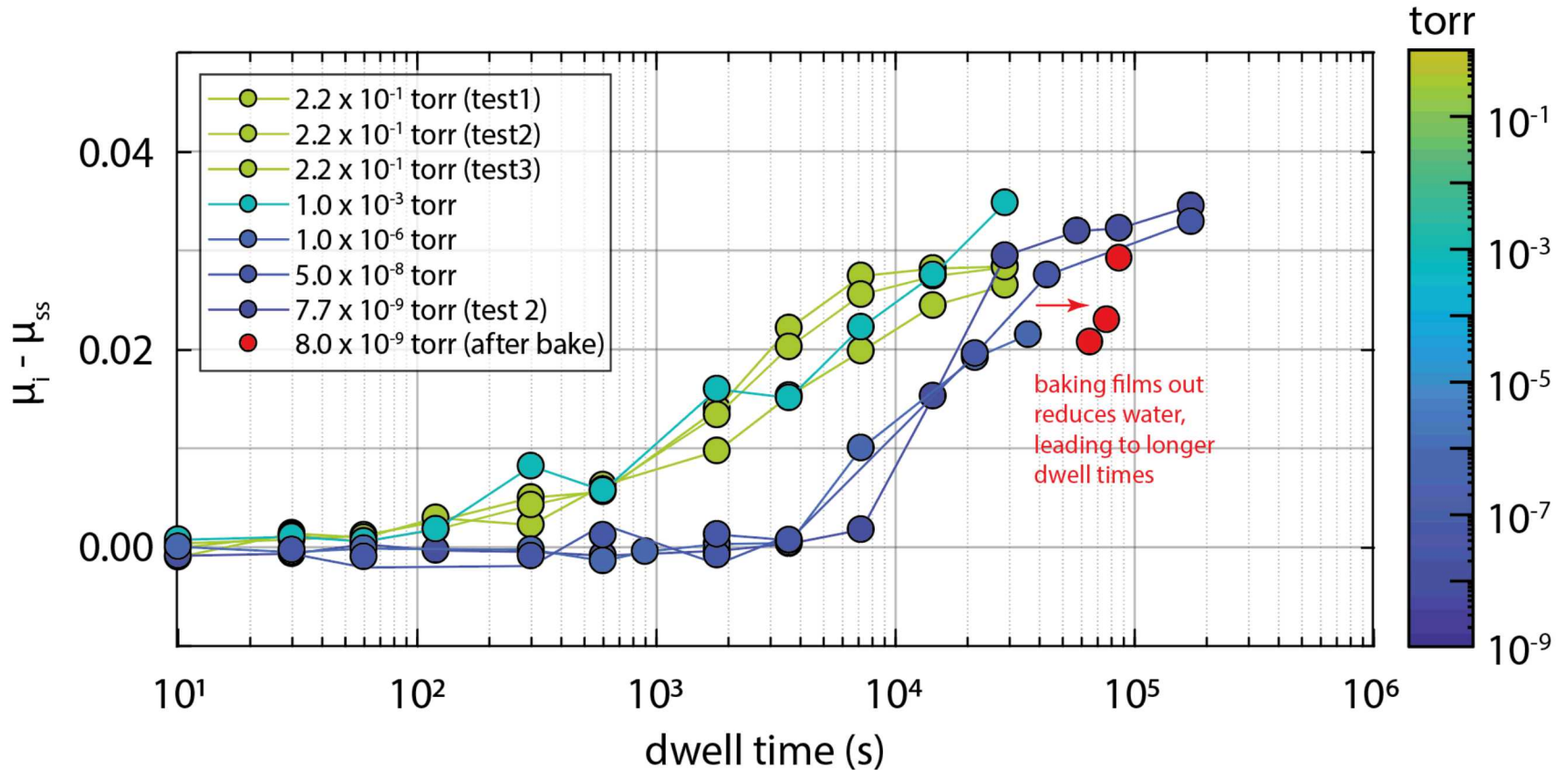
- At low temperature, likely ice or water retained in subsurface
- Noticed prolonged (5K cycle) run-in at -100 C ( $5E-9$  torr) on samples prior to baking out
- Baking films out at 145C for 24 hours greatly diminishes resulting run-in at low temps
- Water likely diminished at surface/subsurface & diffusion much slower at low temps

# Does baking out shutdown re-run-in?



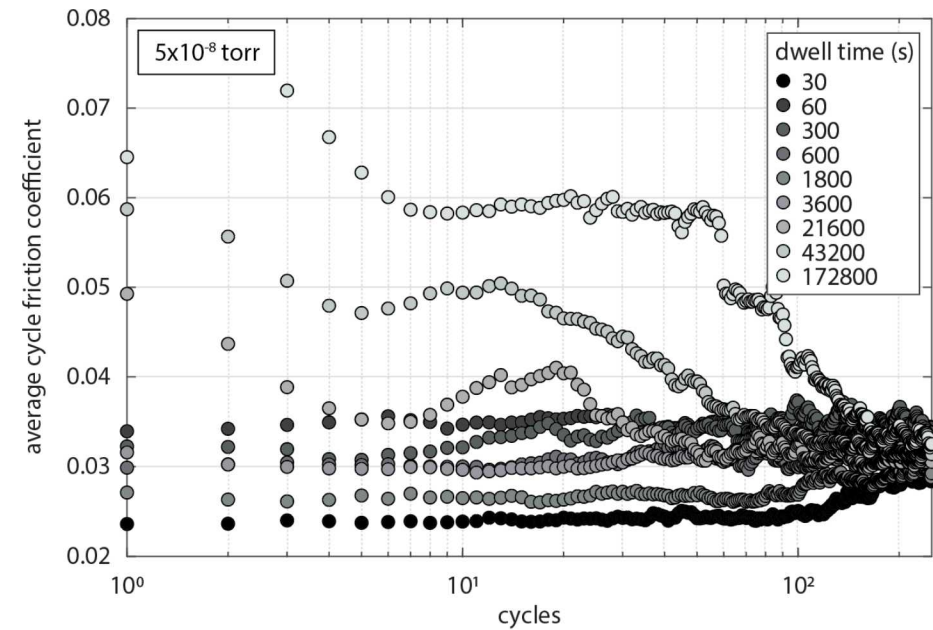
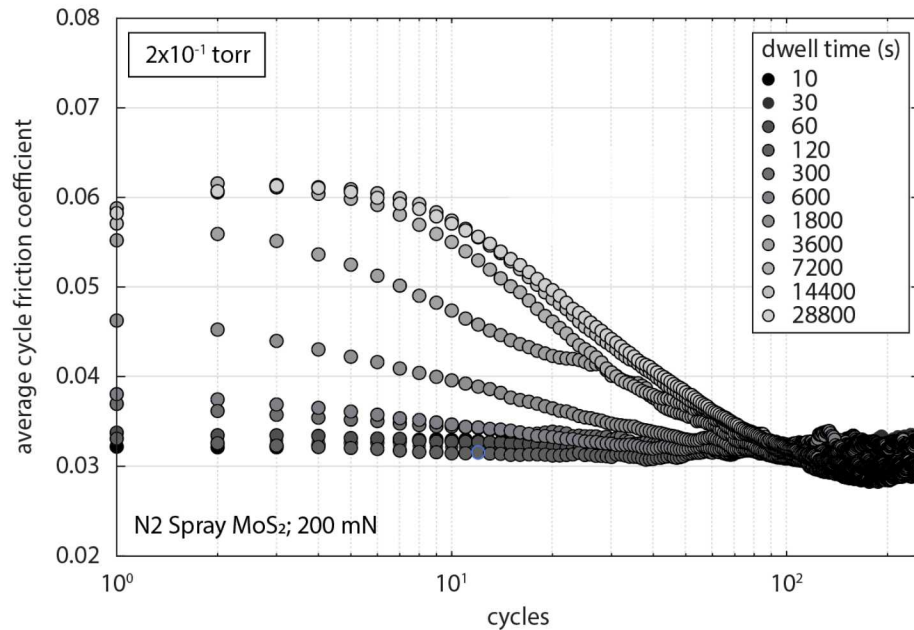
- Dwell times still persist, even after baking out, albeit at longer dwells – lots of water remains

## Does baking out shutdown re-run-in?



- Dwell times still persist, even after baking out, albeit at longer dwells – lots of water remains
- Likely removing water from the surface of the film – reducing concentration and slowing diffusion... more testing necessary

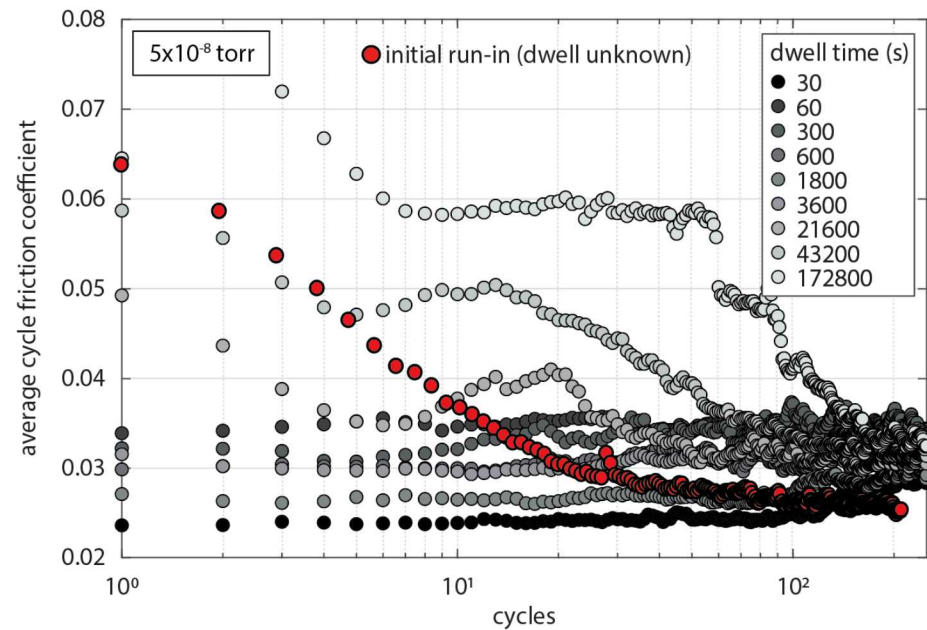
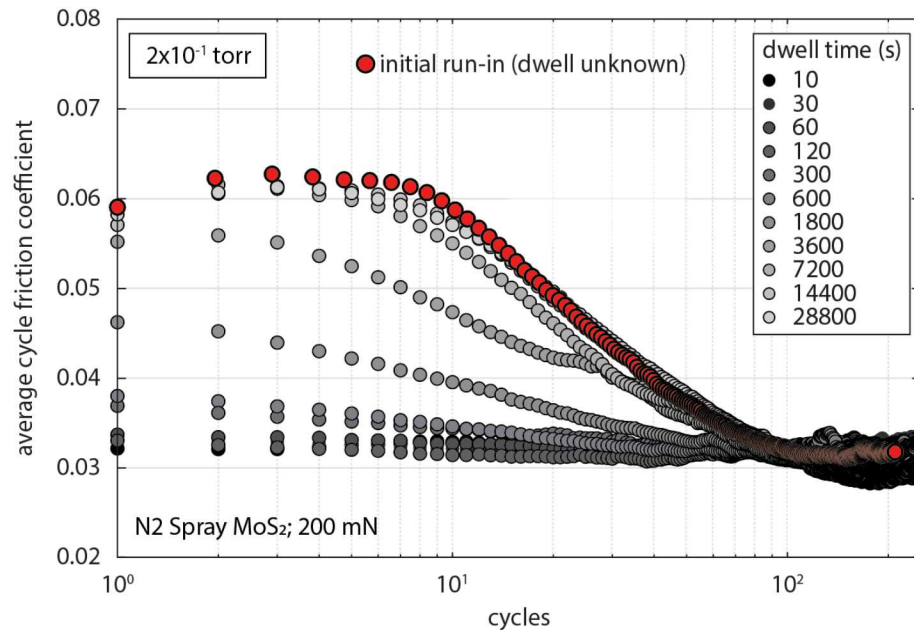
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- Can look back at initial run-in to see how much mechanisms of latent/adsorbed water contribute



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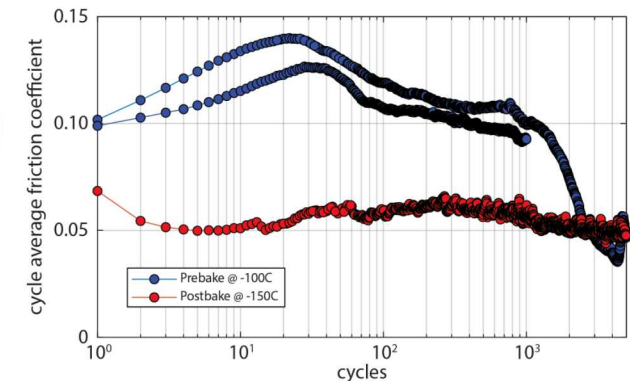
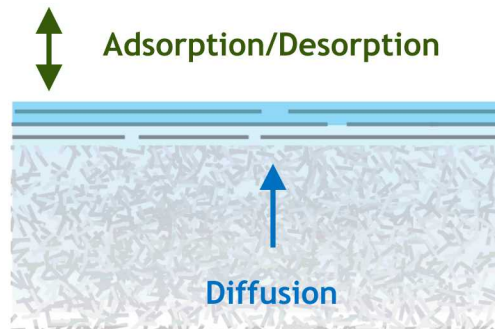
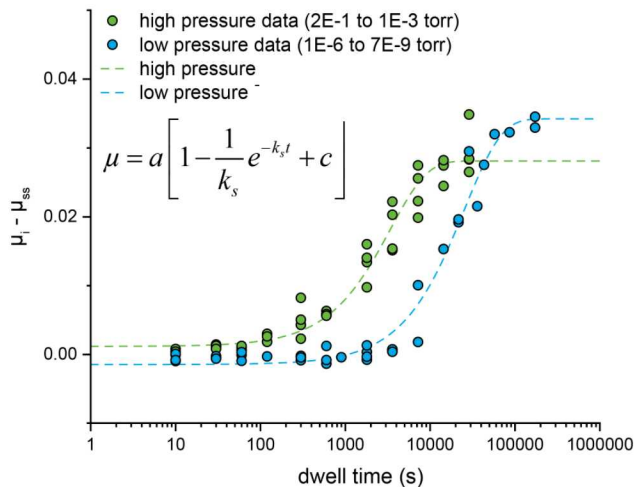


- Can look back at initial run-in to see how much mechanisms of latent/adsorbed water contribute
- High pressure case very convincing – initial run-in very similar to longest dwell re-run-in;
  - Suggests run-in on impinged films may be mostly adsorbate driven, not microstructure
- Low pressure case exhibits same initial friction, but no “shoulders” typically seen
  - Interpretation still incoming; may be initially adsorbed water



# Conclusion

- Re-run-in strongly influenced by adsorbed/latent water, changes with time and pressure and diminished but not eliminated by baking out
- Competing mechanisms in re-run-in behavior at high pressures (adsorption) versus low pressures (diffusion)
- Simple coverage model fits data well, requires tuning and use of relevant materials parameters governing behavior
- Baking out films helps remove water and prolong re-run-in – much water still remains in MoS<sub>2</sub> films
- Future work
  - How temperature/microstructure change diffusivity/sticking prob of contaminants to in re-run-in
  - Tune coating design to aid in minimizing latent water



## The Team

### SNL

Nic Argibay (experimental staff)

Mike Dugger (experimental staff)

Mike Chandross (simulation staff)

Adam Hinkle (simulation postdoc)

Mark Wilson (simulation postdoc)

Brendan Nation (technologist)

John Johnson (technologist)

Morgan Jones (technologist)



### Lehigh U.

Brandon Krick (Professor in Mech. E.)

Tomas Babuska (grad student/intern)

### TAMU

James Batteas (Professor in Chem.)

Quentarius Moore (grad student/intern)



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**ENERGY**



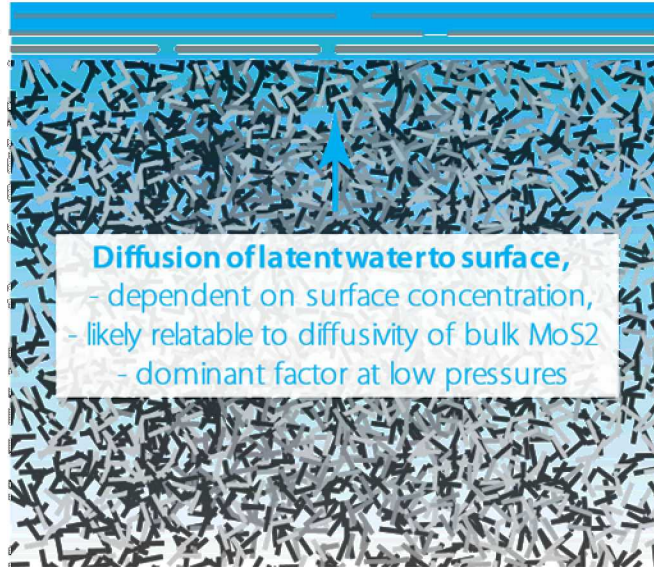
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SURFACE INTERFACES AND MATERIALS  
TRIBOLOGY LABORATORY

# Thanks!



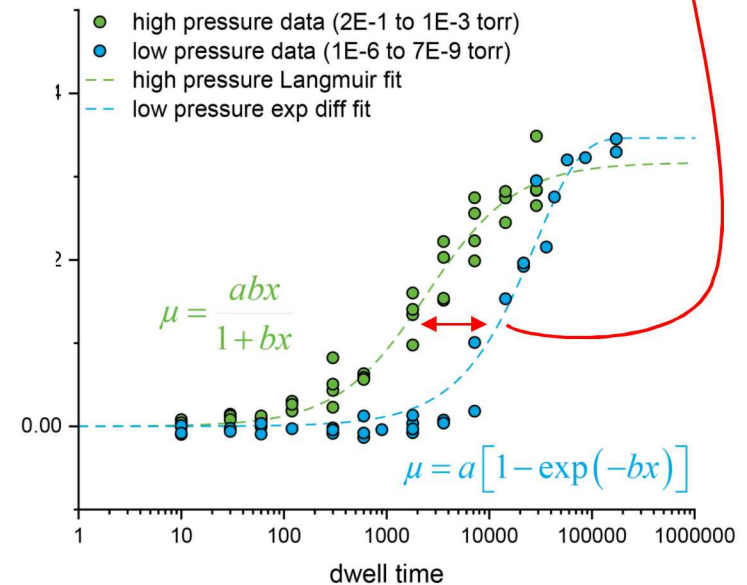
# What's Happening: Proposed Mechanisms of Re-Run-In

Adsorption/desorption in vacuum  
 - water/hydrocarbons - drops off at low pressures with loss of hydrocarbons  
 - dominant factor at high pressures



Oriented surfaces help trap water in the run-in surface/sub surface. More tortuous path providing slower diffusion

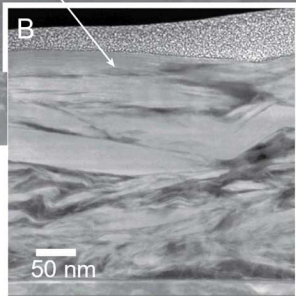
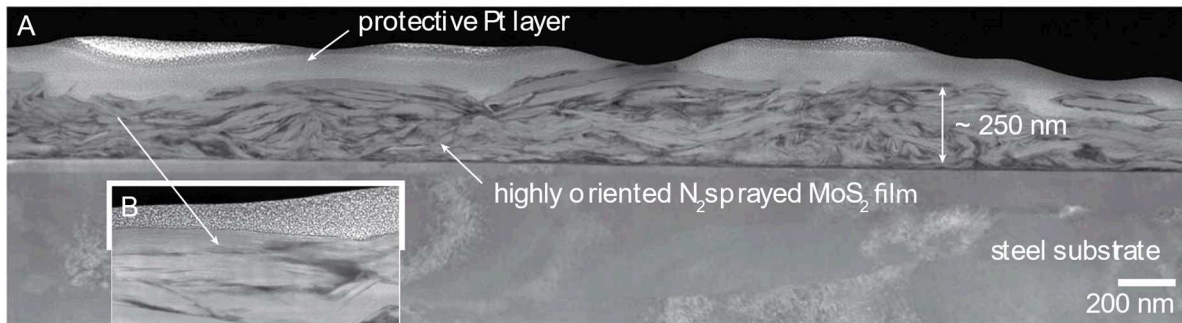
Concentration of contaminants in vacuum do not decrease linearly;  
 different vapor pressures & sticking coefficients



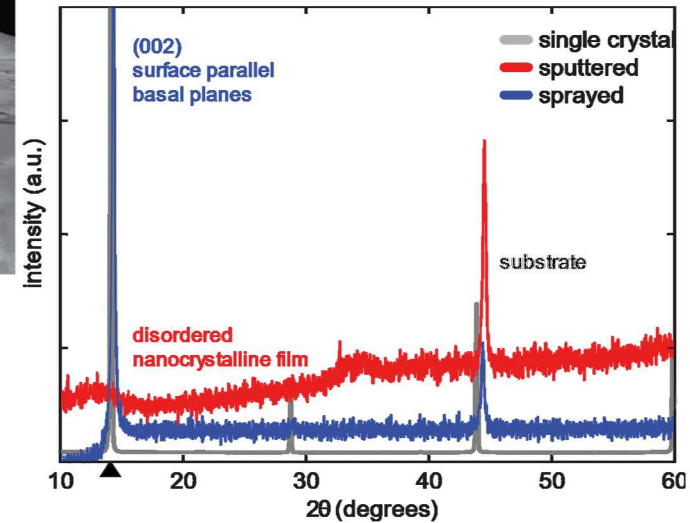
*need more data & functional forms that make physical sense for this application*



# Run Films In before use! Industry Standard! Shows Over!

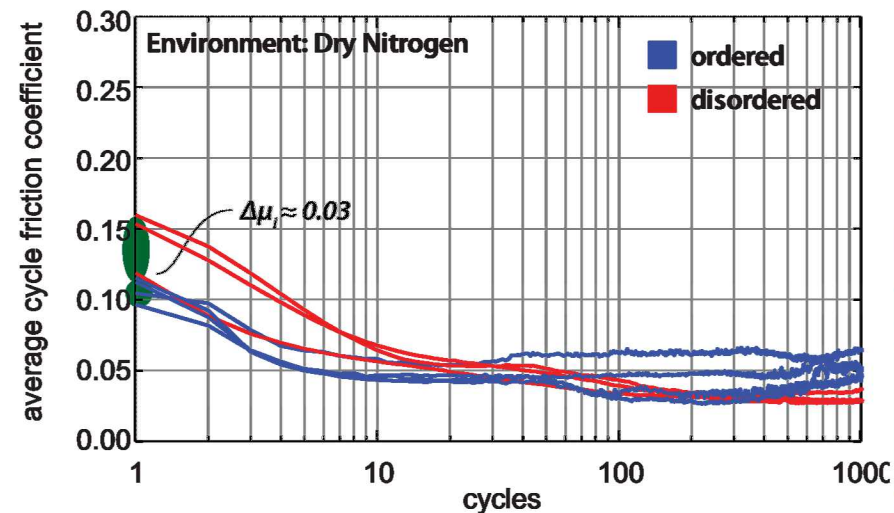


highly ordered (N<sub>2</sub> sprayed) [1]



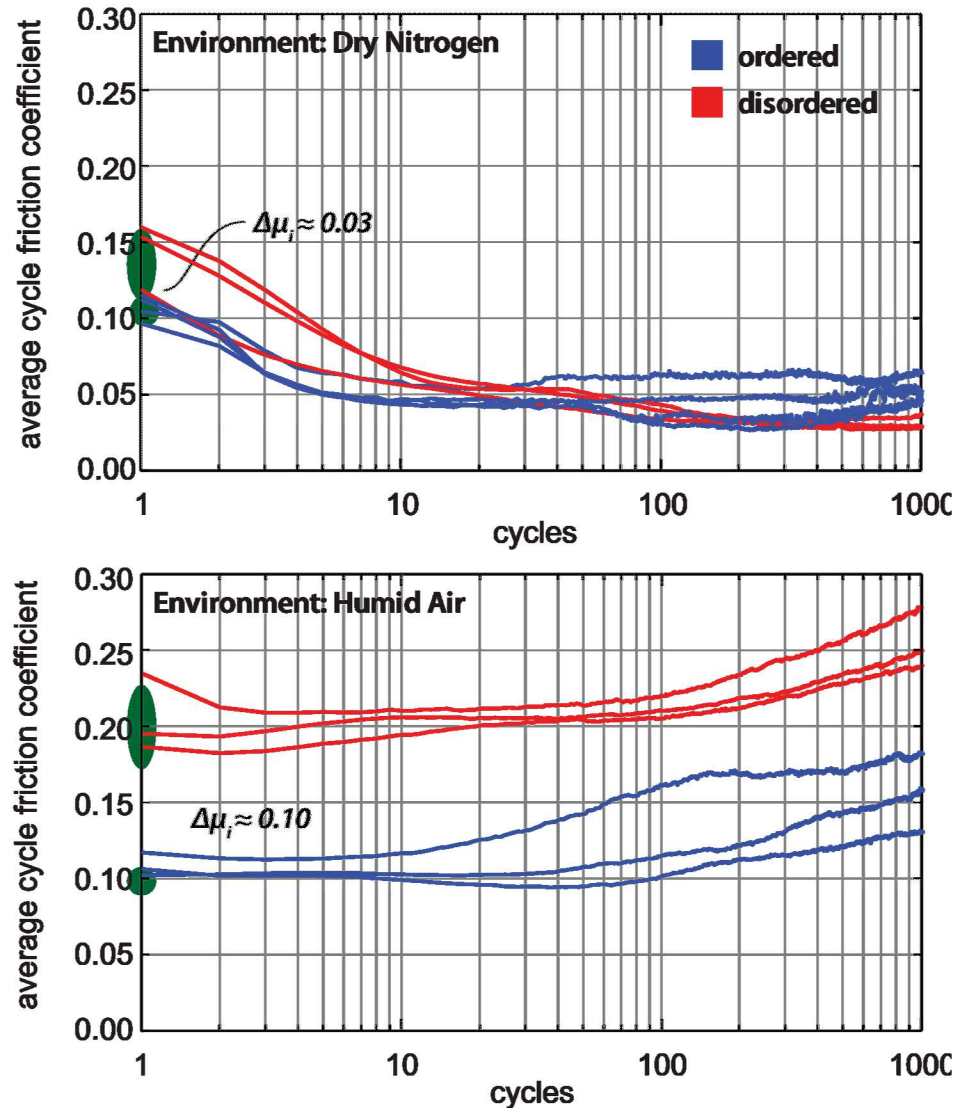
- To make things simple, we focused on ordered, impinged films

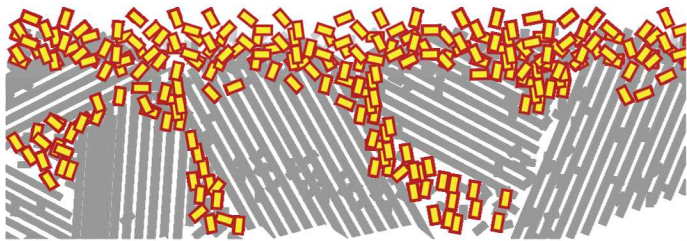
- Little to no reorientation required – exhibit lower initial friction coefficients
- Less susceptibility to environment (Krick)



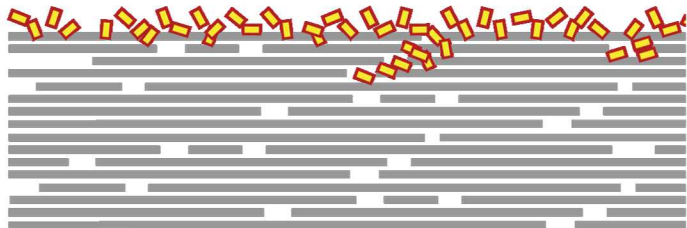
## Run-In Governed by Microstructure

- Sprayed (ordered) films exhibit consistently lower initial friction than sputtered (disordered) films
- Ordered films unaffected by present of water initially
- Where long-range, ordered films exist – they persist. It is hypothesized that water poisons this ability.





***disordered structure***

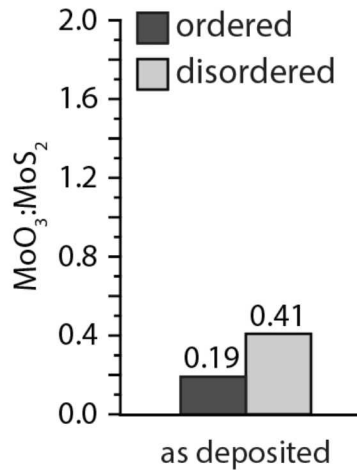


***highly-ordered structure***

- Oxidation resistance should benefit in the same way that run-in does from ordered surfaces
- Higher degree of basal orientation and less available edge site (large crystals) should reduce oxidation
- Ordered structure also provides more tortuous path into the bulk for further interactions

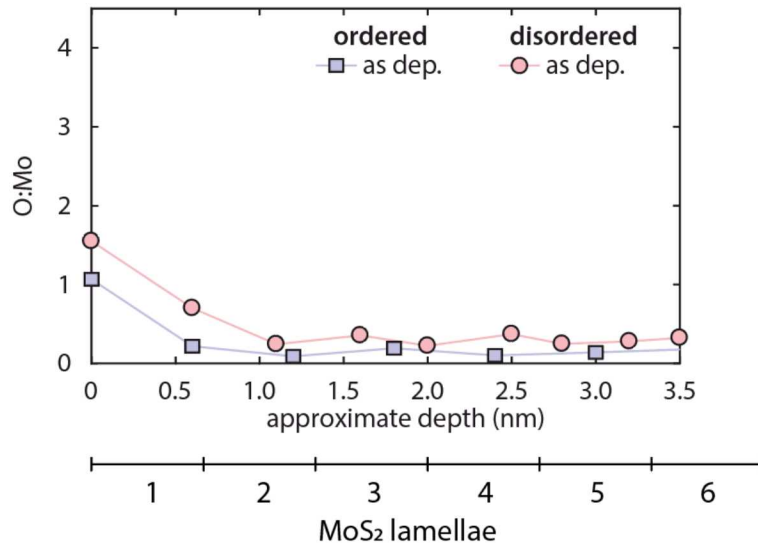
# Oxidation vs Microstructure – XPS & LEIS Study

Mo 3p signal - MoO<sub>3</sub>:MoS<sub>2</sub> ratio



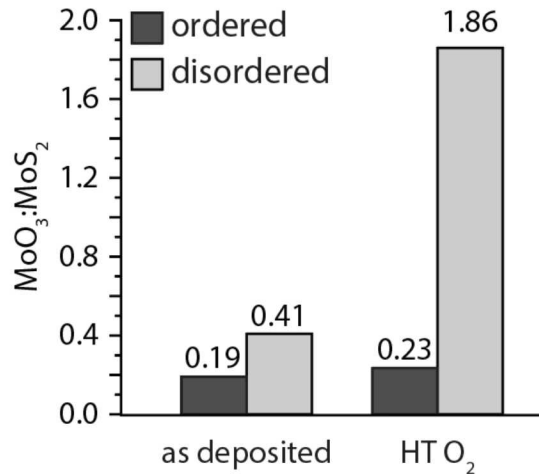
- Look at amount of Mo as sulfide or oxide after exposures to O<sub>2</sub> @ 250C and Atomic Oxygen (30 min)

oxygen : molybdenum ratio



# Oxidation vs Microstructure – XPS & LEIS Study

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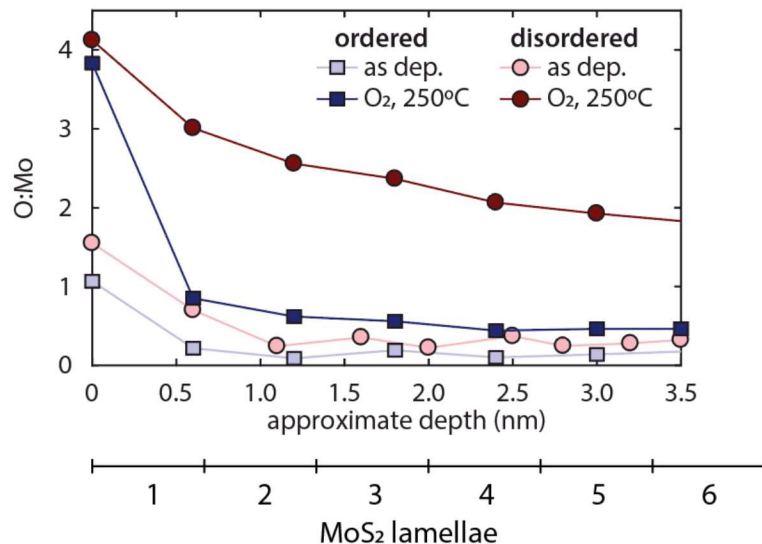
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Oxygen Gas (30 min @ 250°C)

- XPS indicates minimally more oxide for ordered films while disordered films have more

- LEIS shows this is mostly surface limited for ordered films and through the surface for disordered

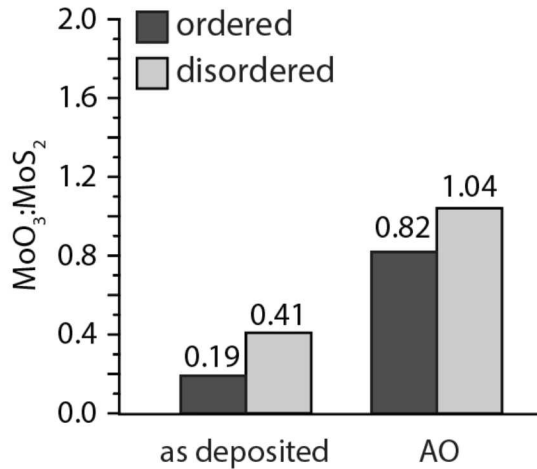
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# Oxidation vs Microstructure – XPS & LEIS Study

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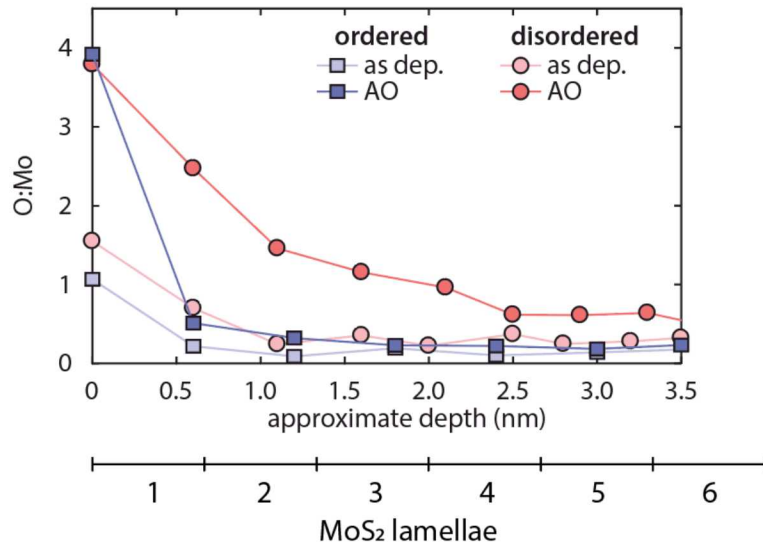
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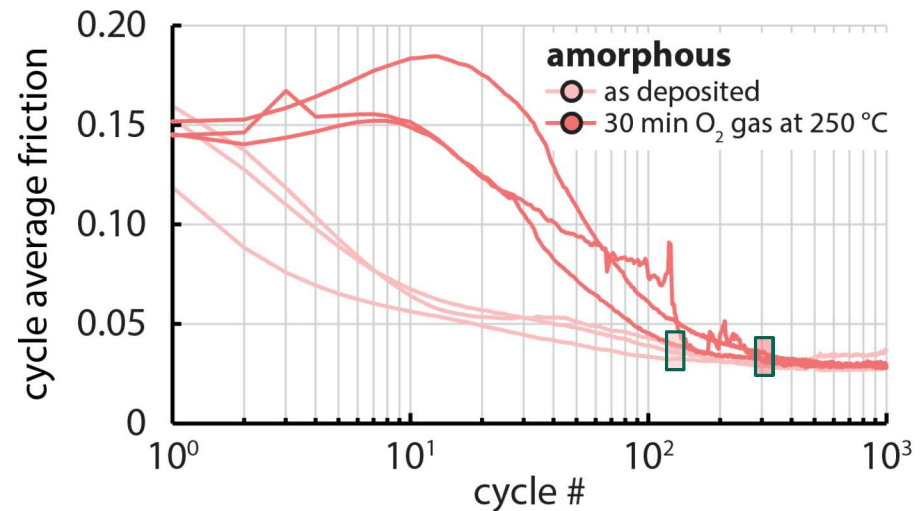
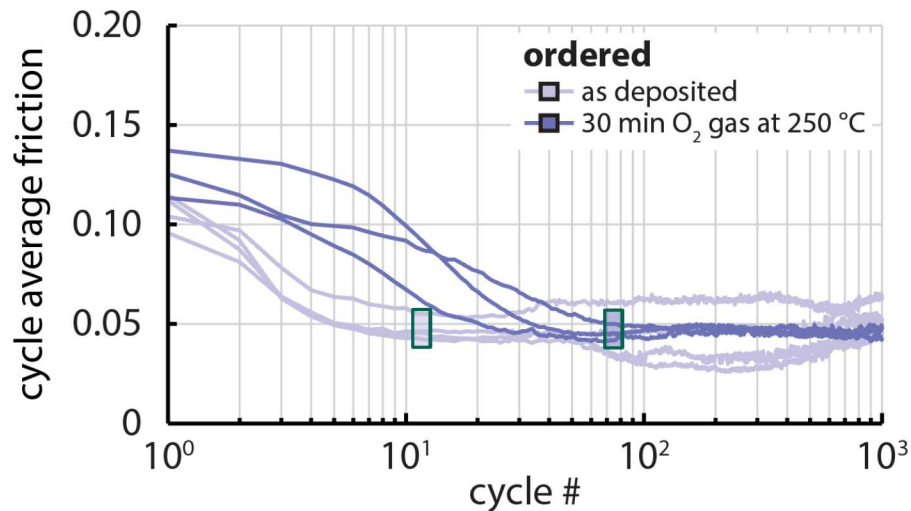


Atomic Oxygen (30 min @ RT)

- AO exposures show similar increases in oxidation via XPS

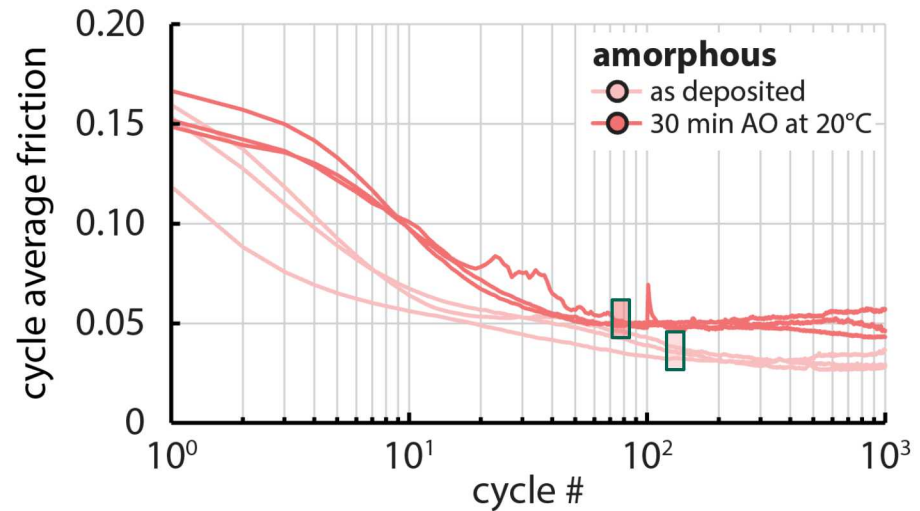
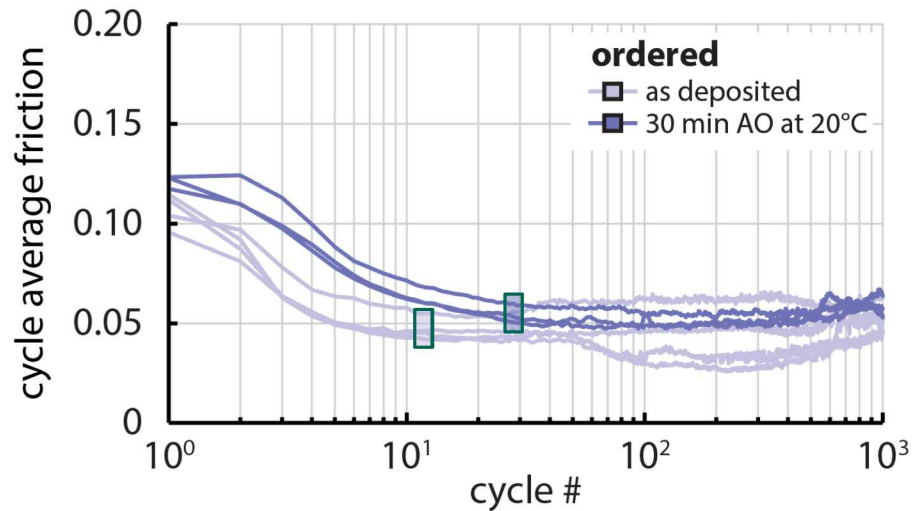
- Again LEIS shows oxygen only at surface for ordered films and not much below the surface for disordered

## Friction comparison for HT O<sub>2</sub> aged coupons



- Exposing Films to oxygen gas at 250 °C for 30 min revealed differences in run-in behavior
- Both films were effected, with disordered films experience much longer high friction run-in phases
- Believe prolonged run-in for disordered films is due to oxygen diffused into the subsurface

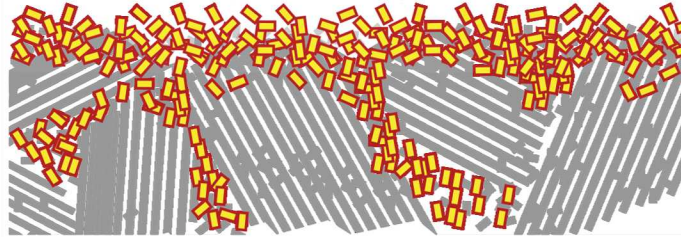
## Friction comparison for AO aged coupons



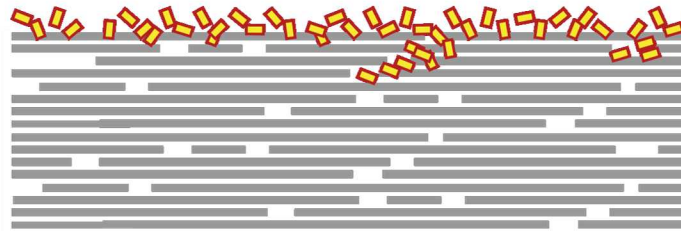
- Exposing Films to atomic oxygen at RT for 30 min revealed minimal differences in run-in behavior
- Attribute the slight increases to thin layer of oxide formed on the surface (confirmed by LEIS depth profile)
- Recent (and past) examples in literature suggest ozone and atomic oxygen form passivating surface layer preventing further interaction with oxygen (Sen et al., J. Appl. Phys, 2014)

## Oxidation vs Microstructure: Mechanisms

High density of edge  
sites at surface  
/subsurface promote  
oxidation with  $O_2$



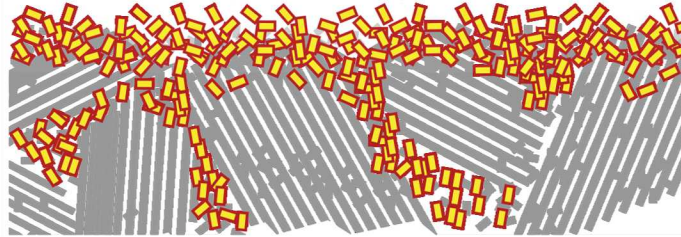
*disordered structure*



*highly-ordered structure*

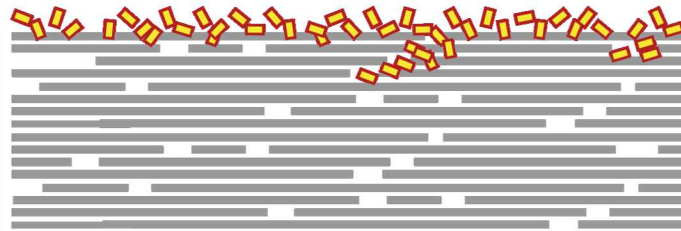
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Ordering limits oxidation to outer surface... ( $O_2$  & AO)

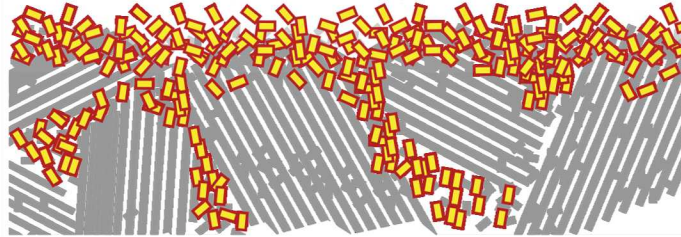


*highly-ordered structure*



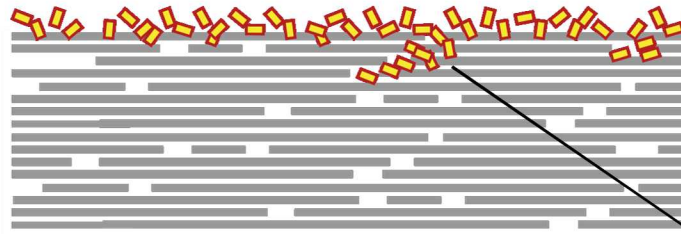
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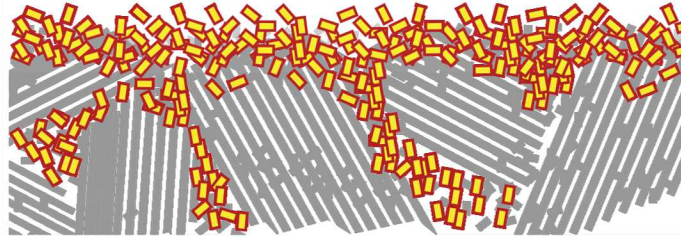


*highly-ordered structure*

$O_2$  only interacts with edges/boundaries... doesn't dissociate on surface

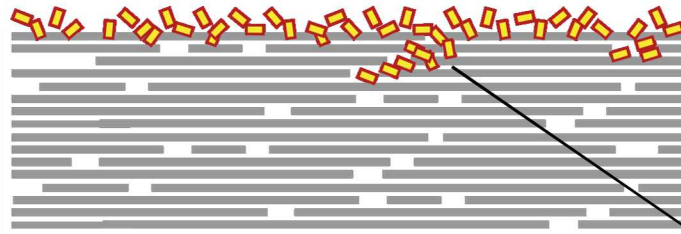
## Oxidation vs Microstructure: Mechanisms

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***disordered structure***

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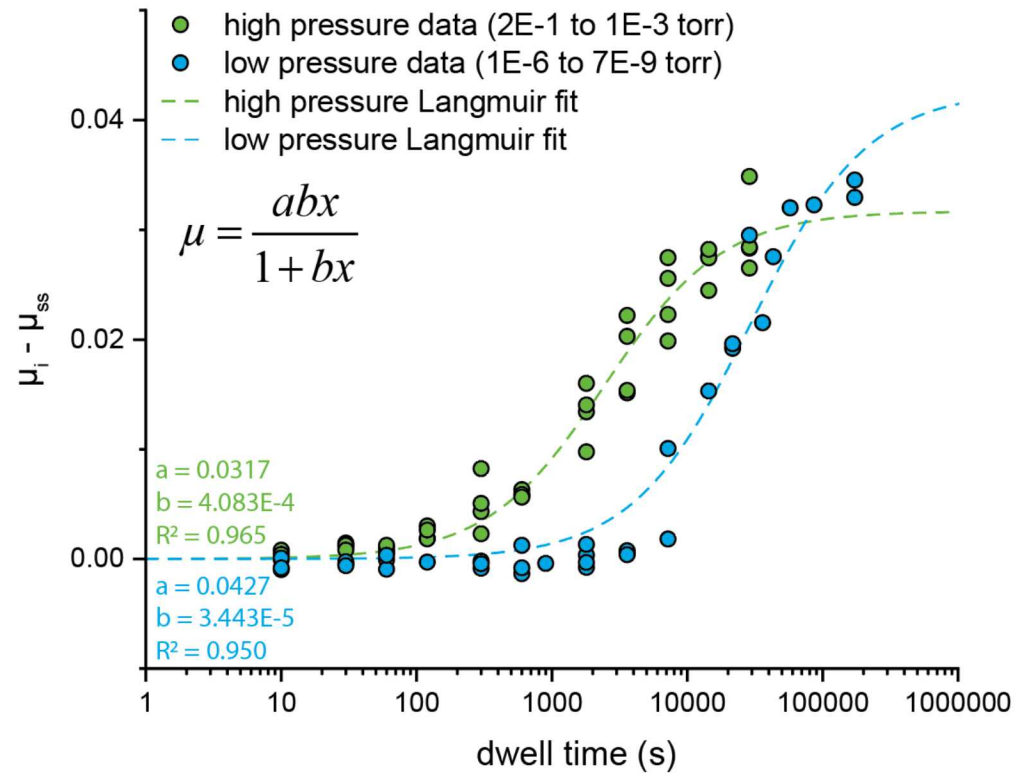
$O_2$  only interacts with edges/boundaries... doesn't dissociate on surface

Oxidation studies on ordered and disordered films reveal the importance of large, basally oriented phases in preventing oxidation

# Langmuir Equation – Adsorption Approximation

- If adsorption/desorption are at play, Langmuir might help explain results

- Adsorbate behaves as ideal gas at isothermal conditions; describing the fraction of occupancy of an adsorbent at possible adsorption sites

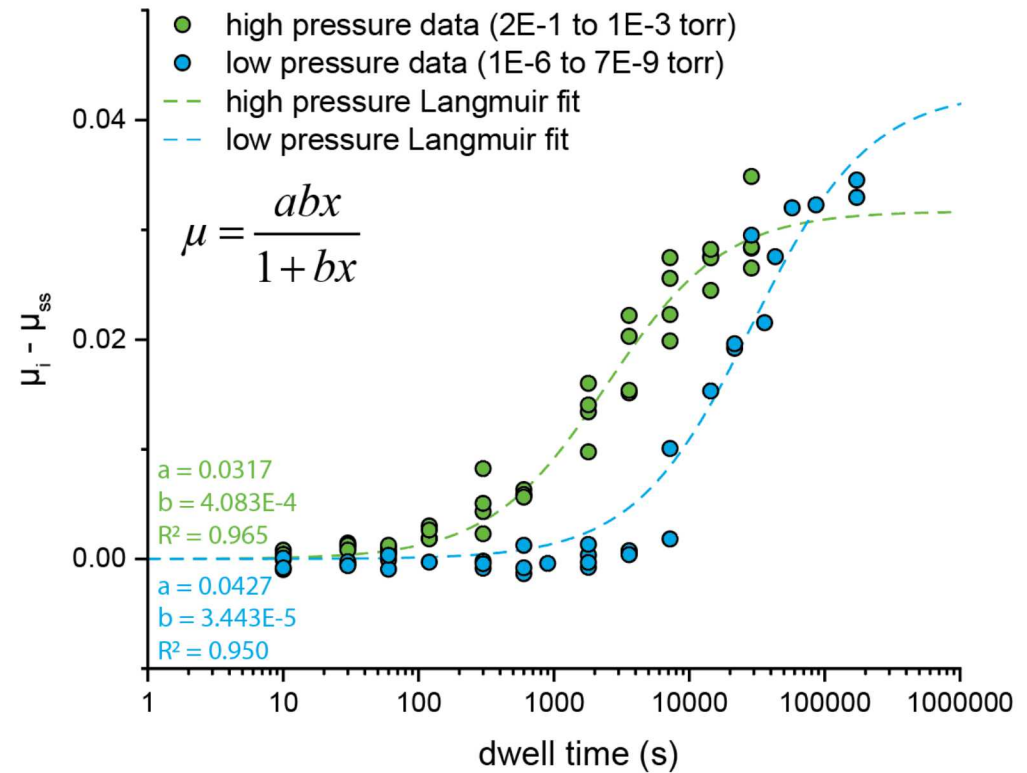


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## *Treating pressure as time?*

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# Langmuir Equation – Adsorption Approximation

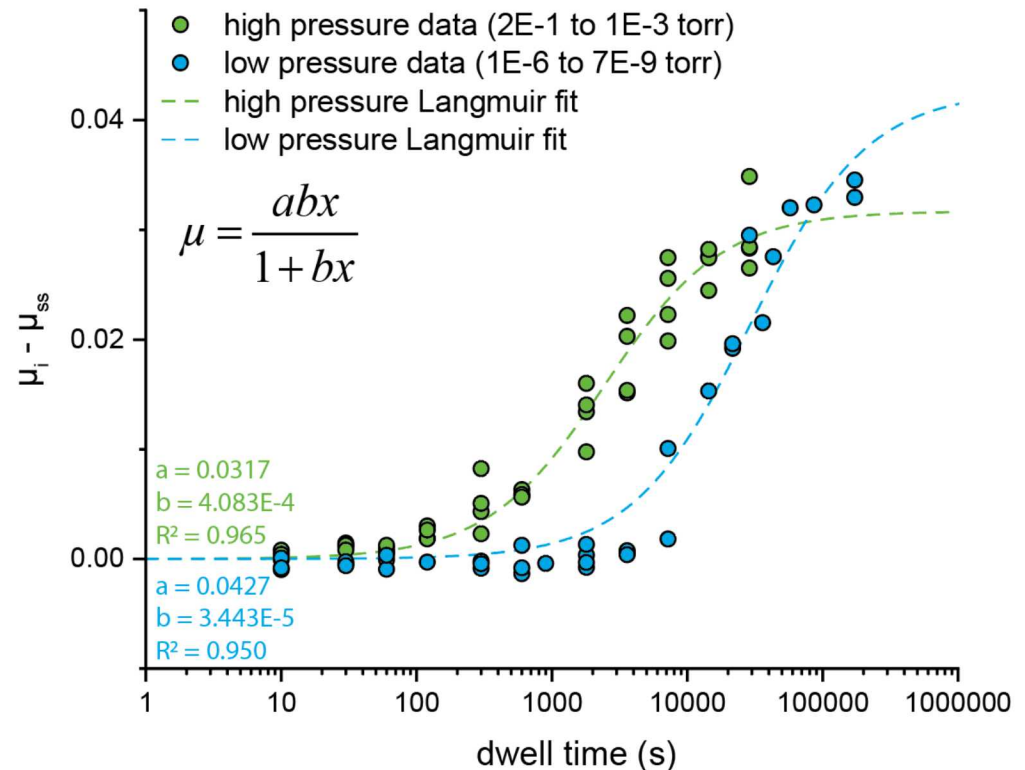
- If adsorption/desorption are at play, Langmuir might help explain results

## *Treating pressure as time?*

- Adsorbate behaves as ideal gas at isothermal conditions; describing the fraction of occupancy of an adsorbent at possible adsorption sites

- Fits the high pressure curves better, not capturing the roll-off at long dwell times for low pressures

- Certain assumptions may not apply
  - Absence of corrugation
  - All sites being equivalent (basal vs edge)
  - Adsorbate interactions (water vs hydrocarbons)

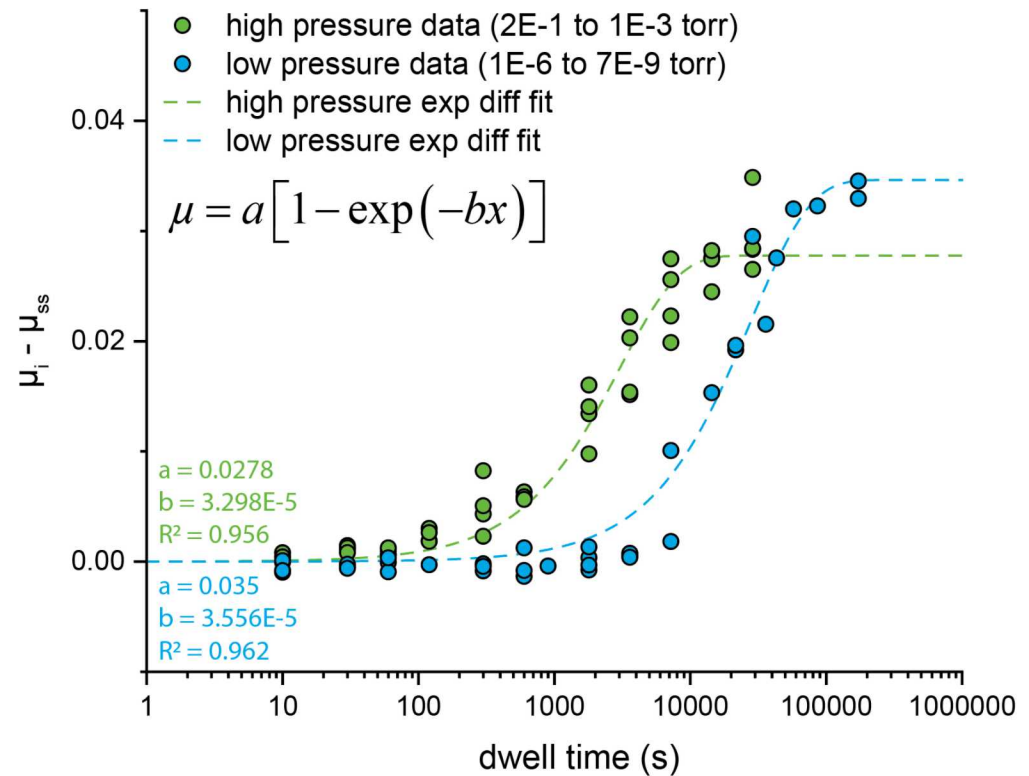




# Exponential Growth – Diffusion Approximation

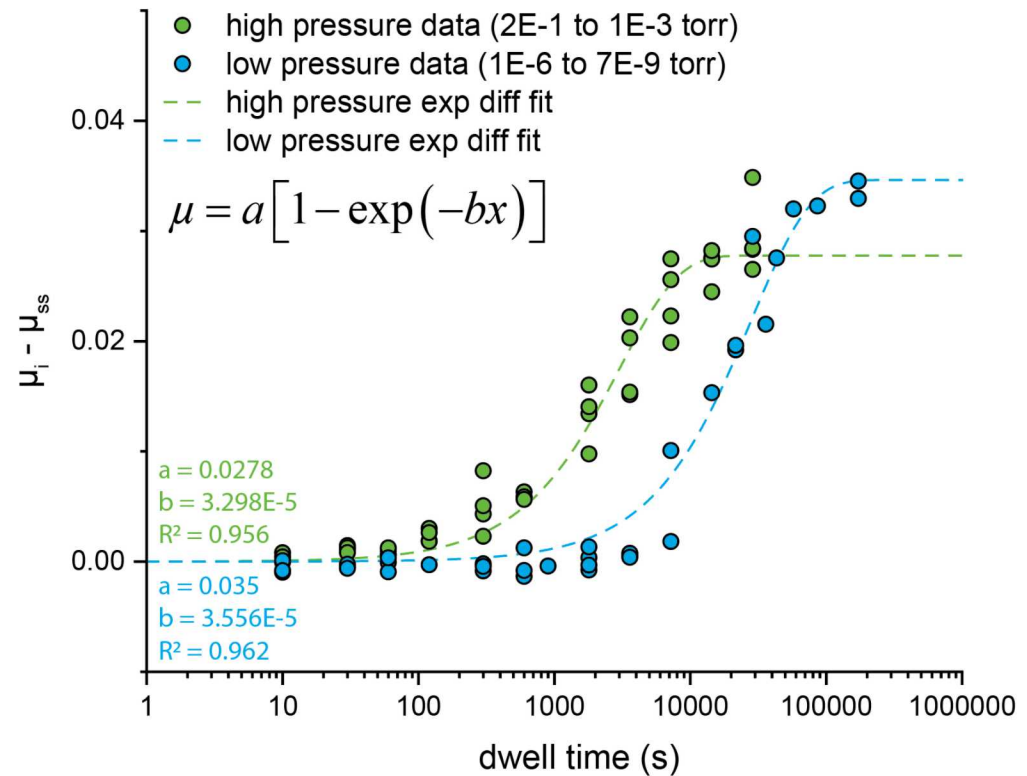
- As Matsunaga suggested – behavior might be best described by diffusion processes

- Borrowed models from surface concentration via grain boundary diffusion...



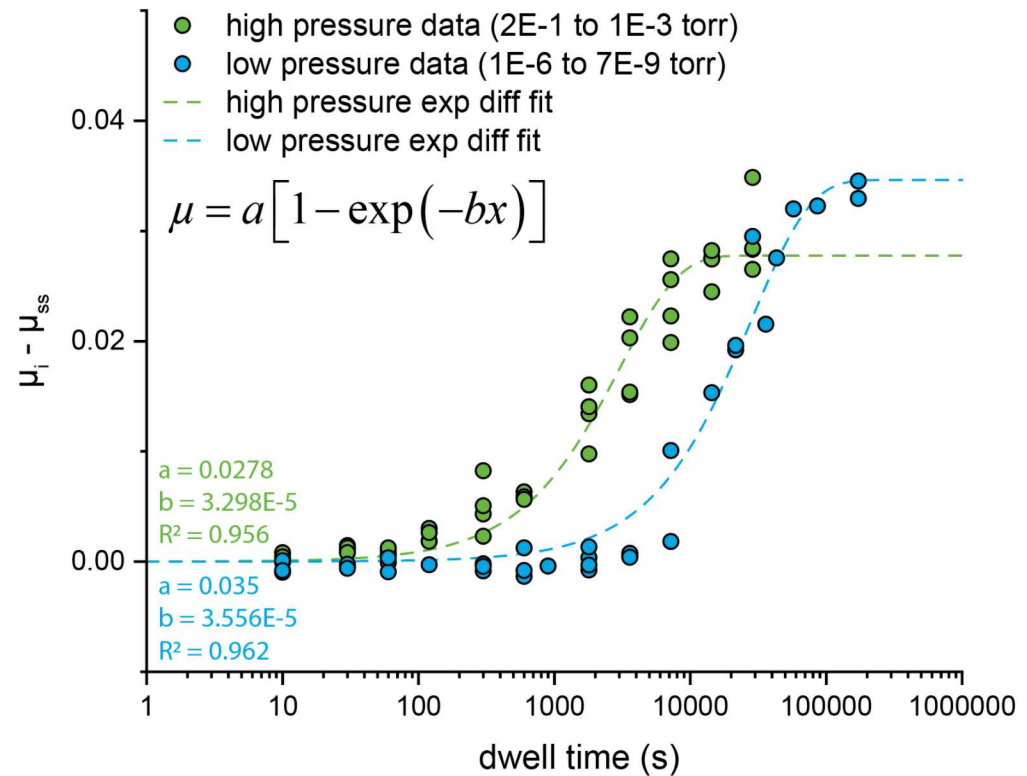
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- Unsure of physical meaning in model, would need to relate to materials parameters



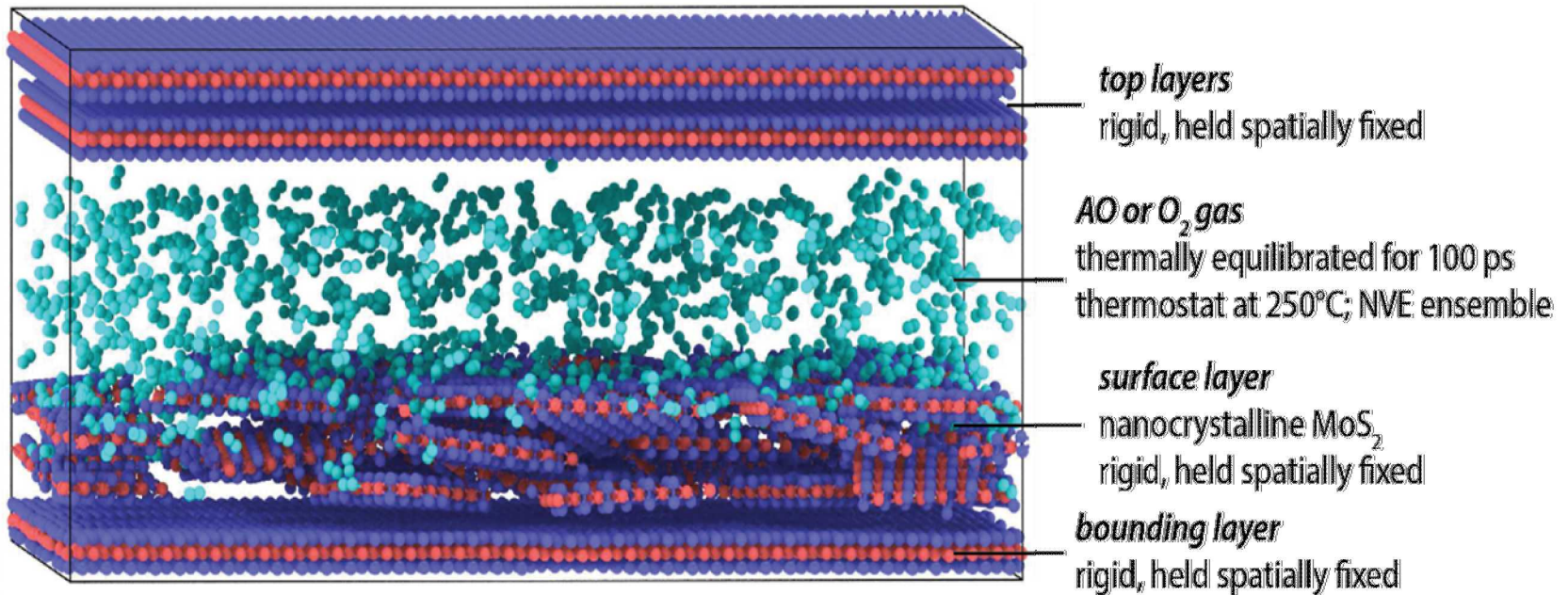
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**“All models all wrong - but some are useful” - G. Box**

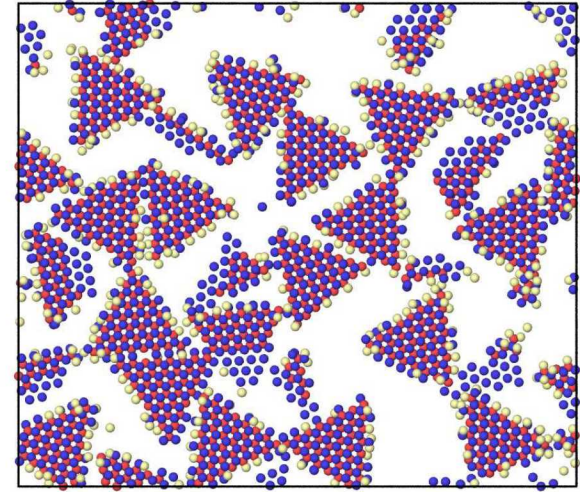
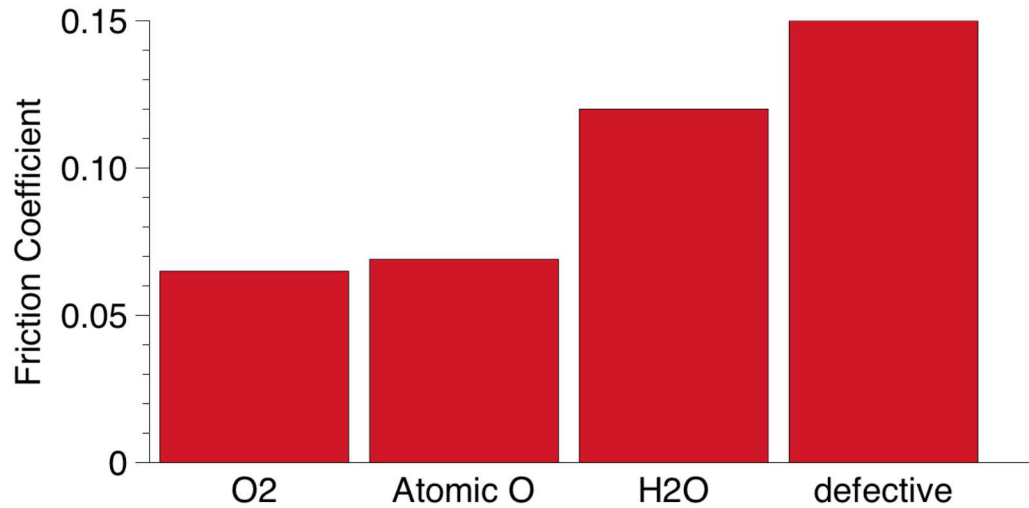
# Molecular Dynamics Approach



- Take systems that have “run-in” (i.e. reached steady-state shearing)
- Remove top layers
- Apply O<sub>2</sub>, AO or H<sub>2</sub>O at 100 atm
- Replace top layers

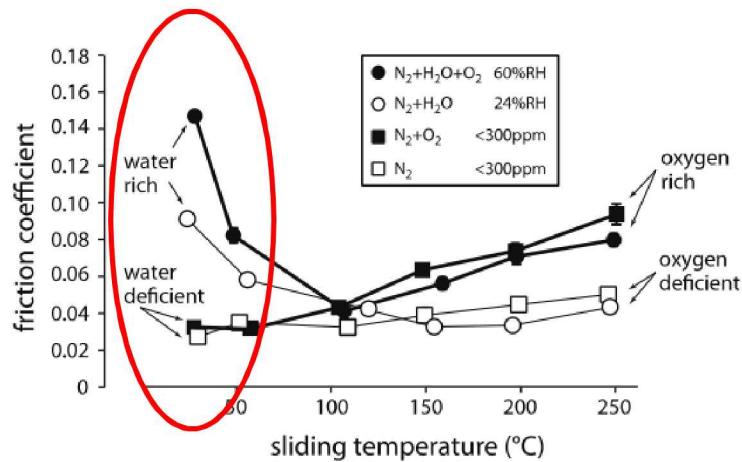


## How do oxygen and water interact?

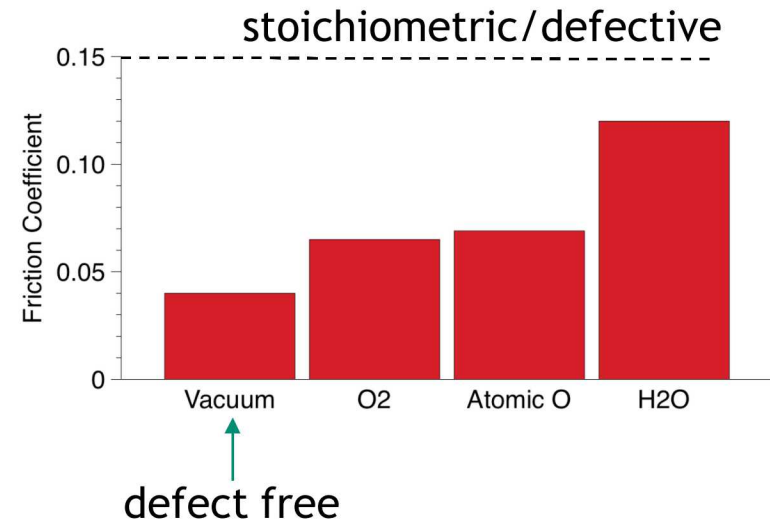


- Friction goes down?
- This is unfair...
  - Water and oxygen passivate defect sites
  - Need to do this in the pure system, too
  - Look at non-stoichiometric (i.e. defect-free) nanoplatelets

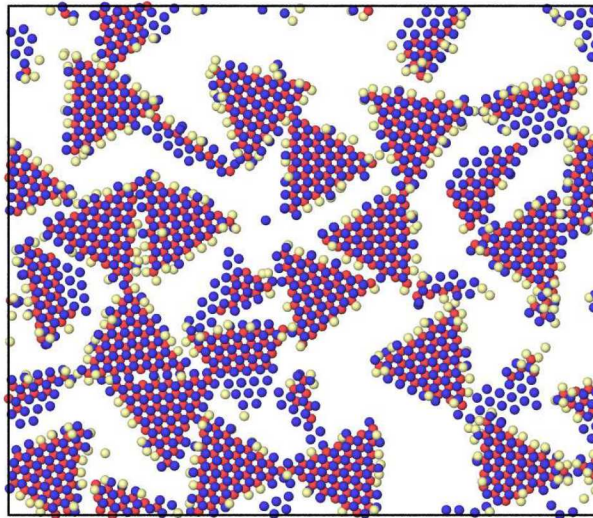
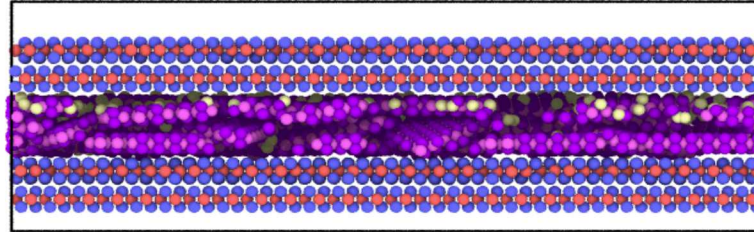




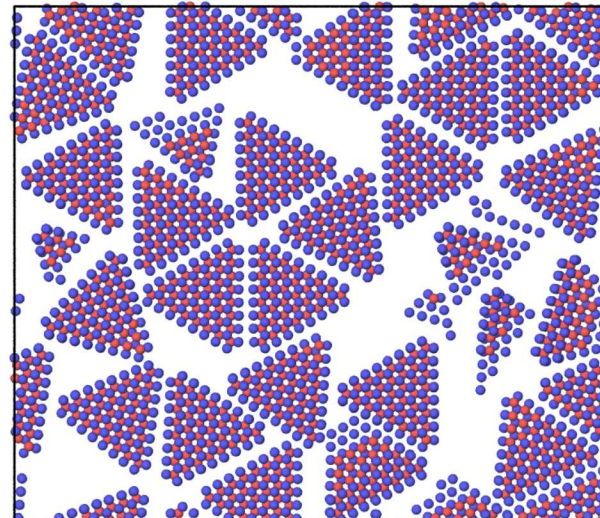
Khare and Burris, Tribol. Lett. 2013



- Changes with added oxygen or water match experimental results

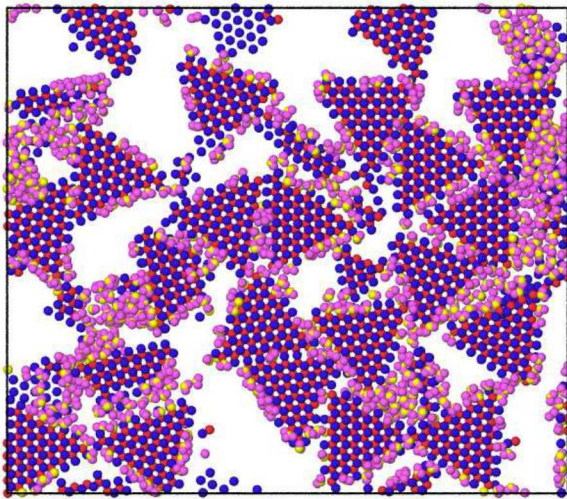


oxygen passivated

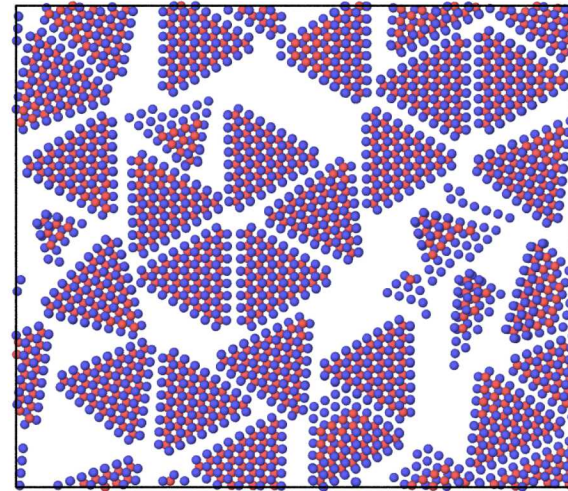


defect free

- Oxygen bonds to defect sites & prevents formation of larger sheets
- Molecular oxygen looks very similar



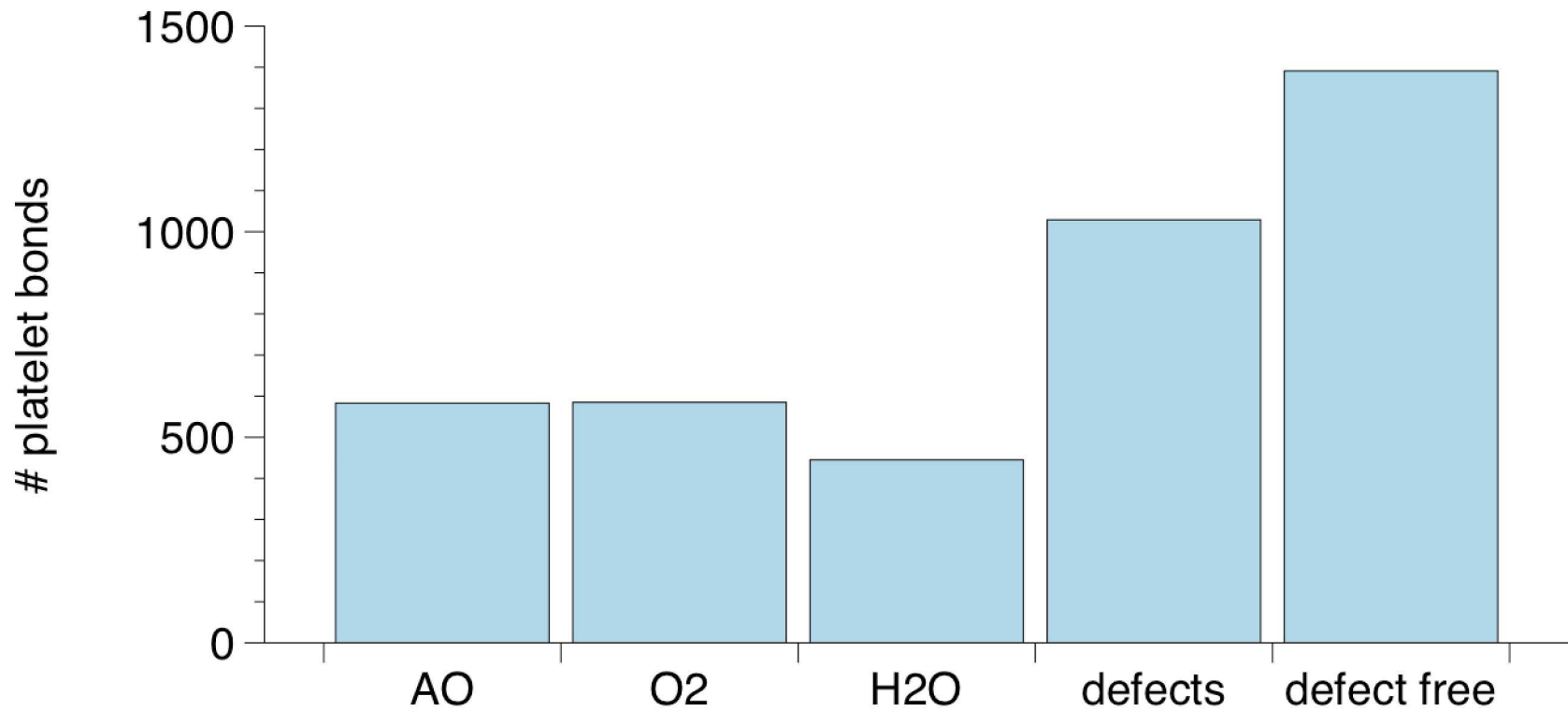
water passivated



defect free

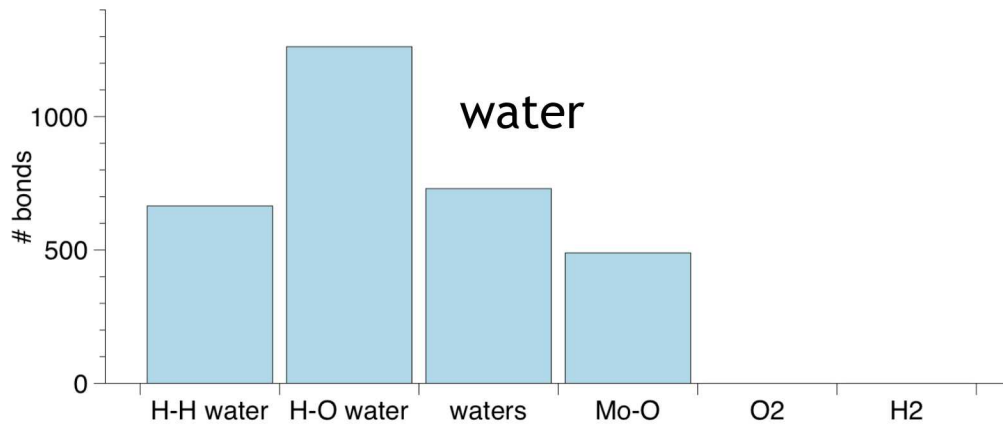
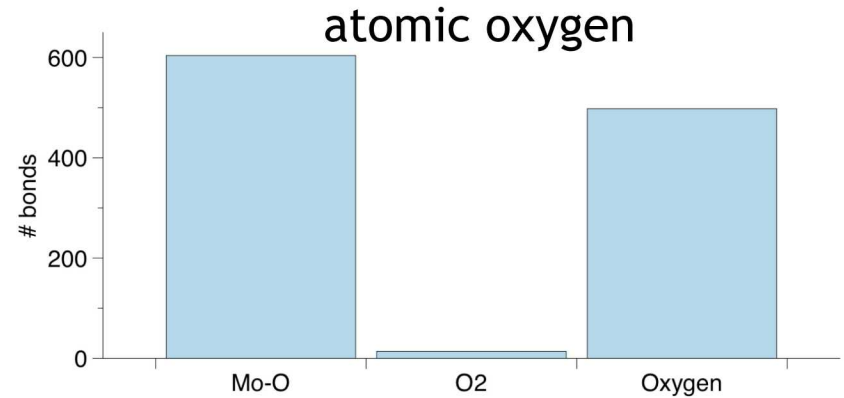
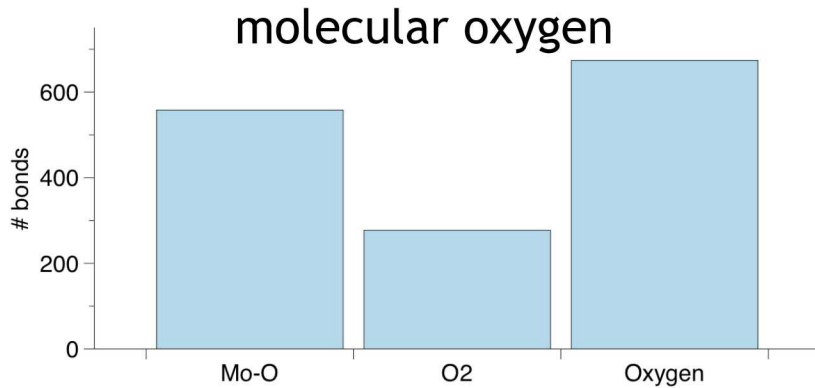
- Water also bonds to defect sites & prevents formation of larger sheets
- Water aggregates with itself more than oxygen does

## Counts of inter-platelet bonds confirm



Environmental species interrupt formation of larger flakes

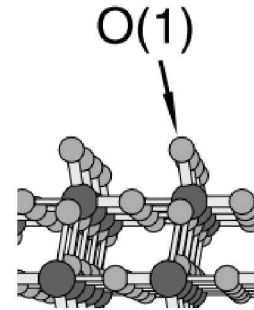
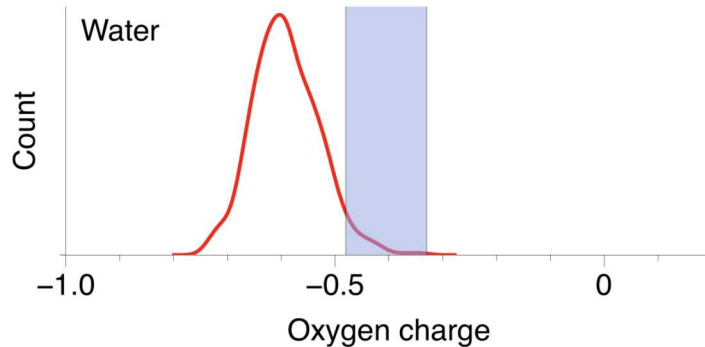
# What can we say about chemistry?



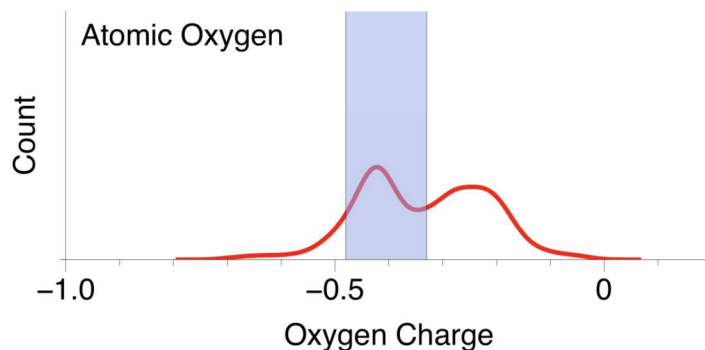
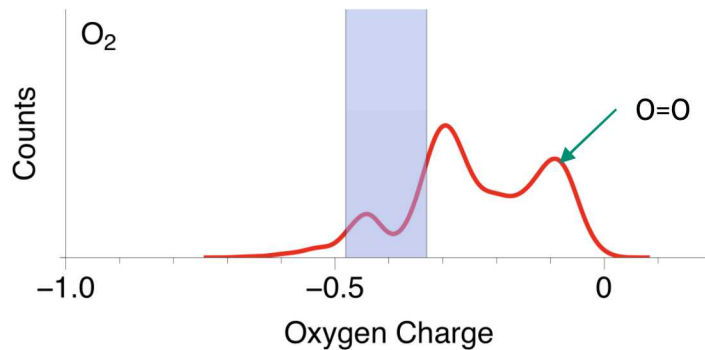
- Water does not dissociate (no O2 or H2 formed)
- Molecular O shows little dissociation (mostly in O2)
- Atomic oxygen forms little O2



# Charge on Oxygens confirms chemistry



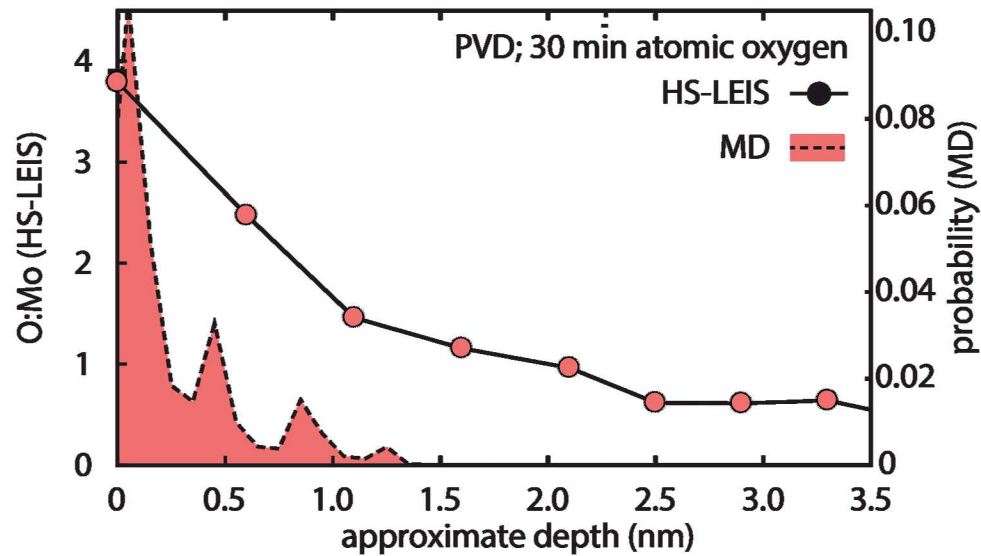
Tokarz-Sobieraj et al.  
Surf. Sci. 2001



- Oxygen bonded to Mo has partial charge from -0.48 (Tokarz-Sobieraj et al. Surf. Sci. 2001) to -0.33 (Yin et al., J. Mol. Model 2001).
- Oxygen in water has partial charge from -0.6 to -0.8 (Astrand, et al., J. Phys. Chem. A 1998).
- Water shows only physisorption
- Atomic oxygen shows chemisorption
- Molecular oxygen shows slight amount of chemisorption

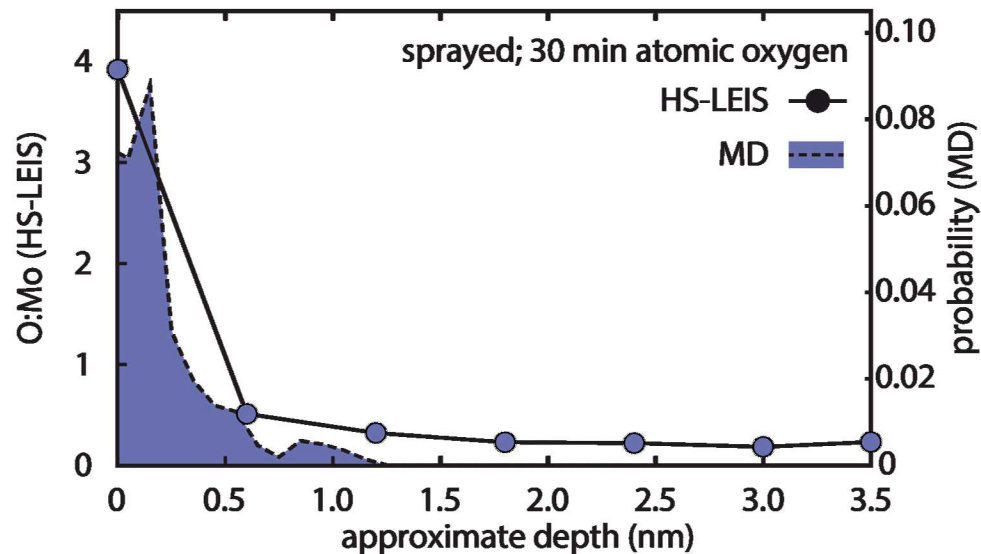
- MoS<sub>2</sub> shows purely elastic contact
- Shear is predominantly due to inter-lamellar interactions
- Simple model predicts temperature dependence
- Environment hinders formation of large sheets
- No chemistry with water
- Little chemistry with molecular oxygen
- Lots of chemistry with atomic oxygen

# LEIS & MD Depth Profiles



## sputtered (nanocrystalline/amorphous)

- oxygen at surface of coating
- oxygen slowly decays after several lamellae

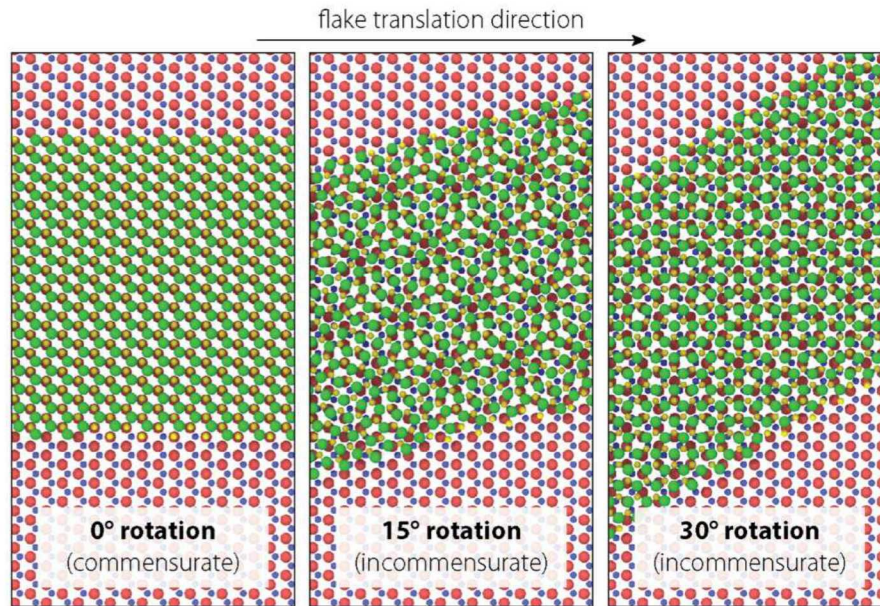


## sprayed (highly ordered film)

- oxygen at surface of coating
- decays quickly after ~ lamellae

*MD accurately represents oxygen depth profiles as seen in LEIS experiments*

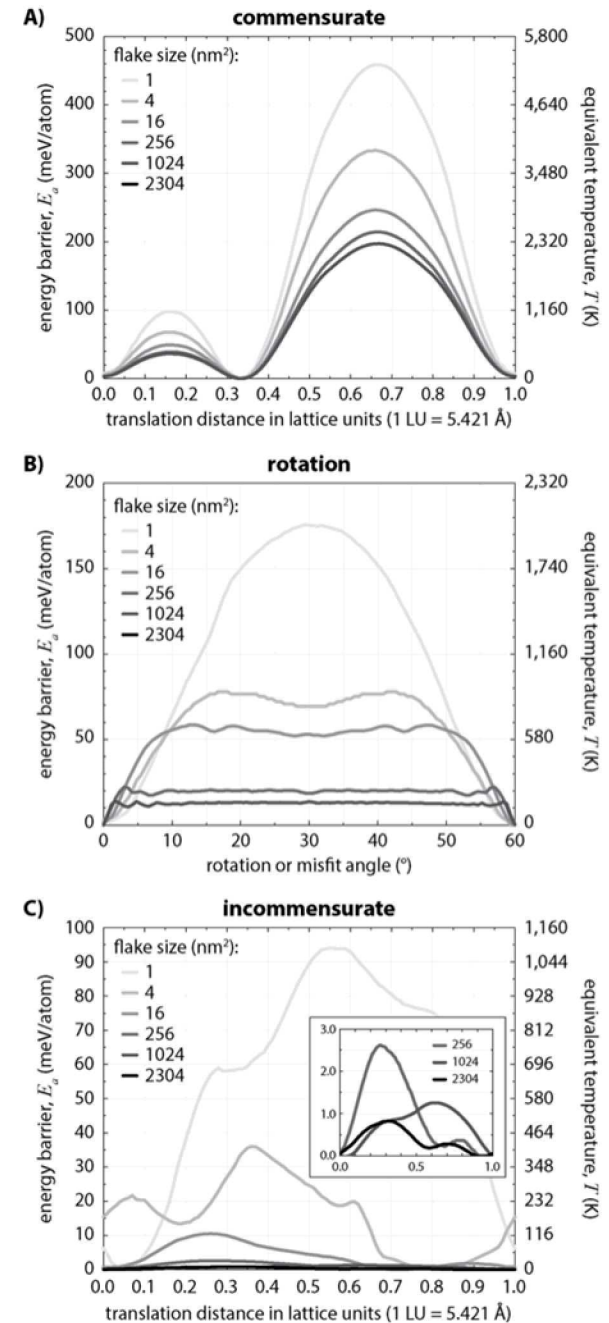
# Elastic contact => Energy Barriers: Our work



commensurate  
egg shell



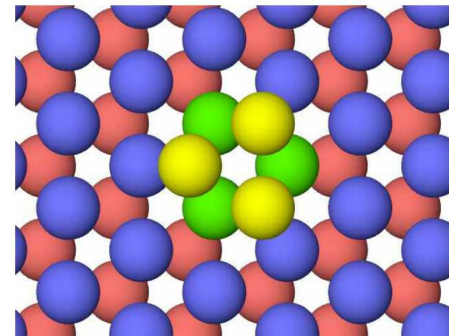
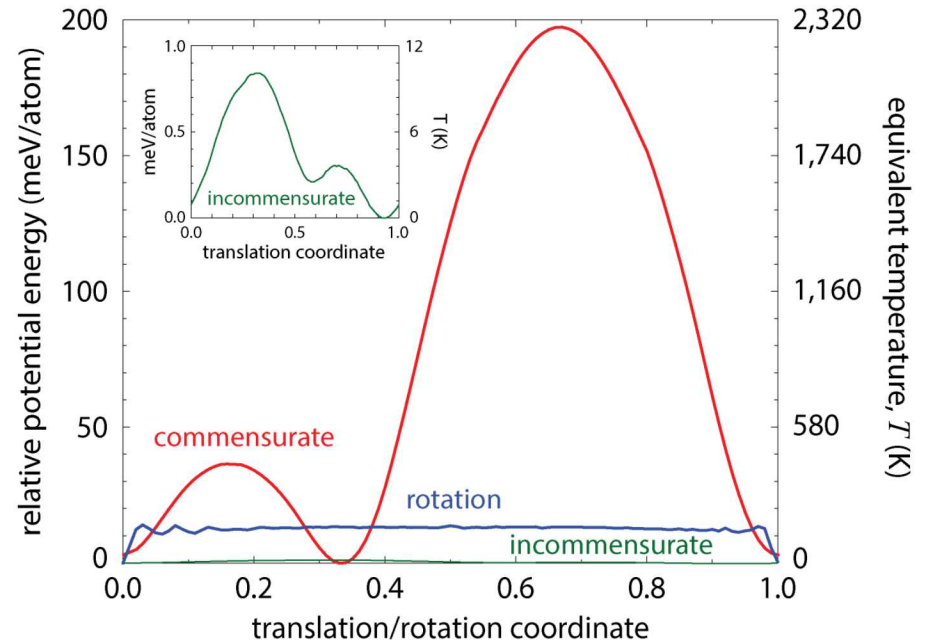
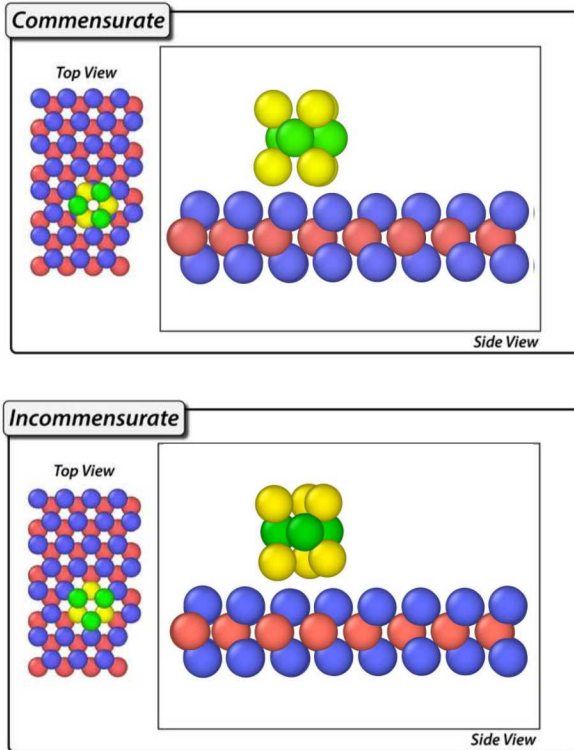
incommensurate  
egg shell



Nudged elastic band calculations for barriers



# Commensurate vs. Incommensurate Sliding

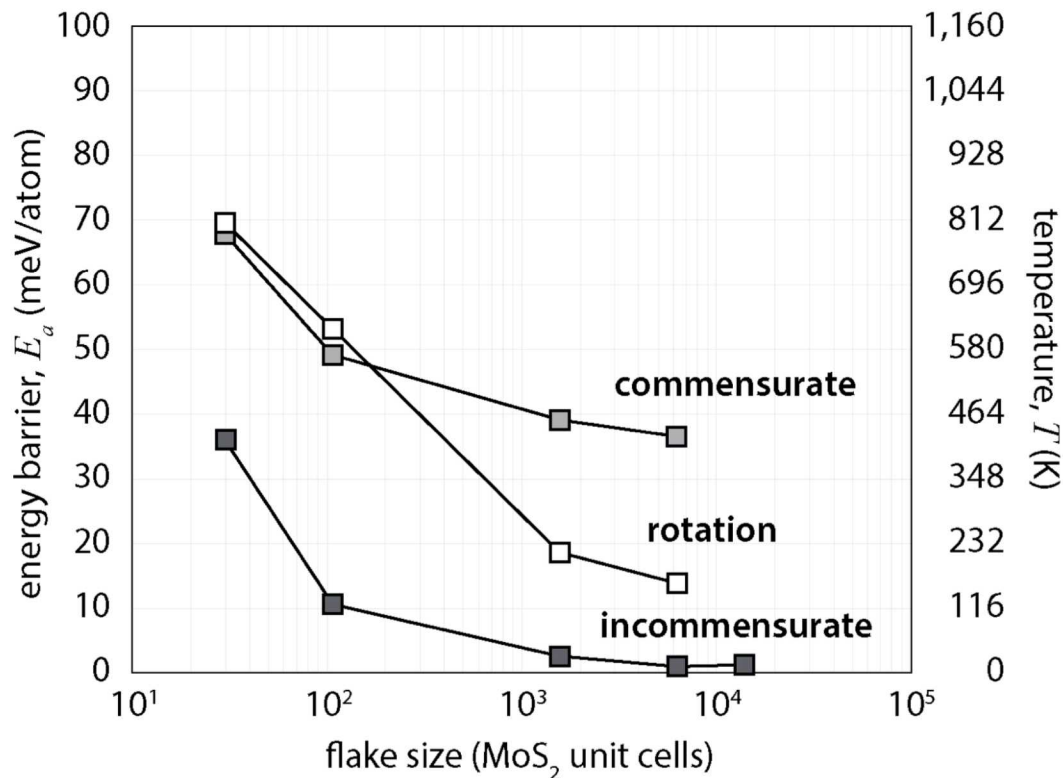


rotation

- Commensurate barrier  $\sim 300$  K
- Incommensurate barrier  $\sim 10$  K
- Rotation barrier  $\sim 150$  K



# Barriers converge with increasing flake size; make a toy model



Probability & Failure to cross barrier:

$$p_n \propto \exp\left(\frac{-E_n}{kT}\right)$$

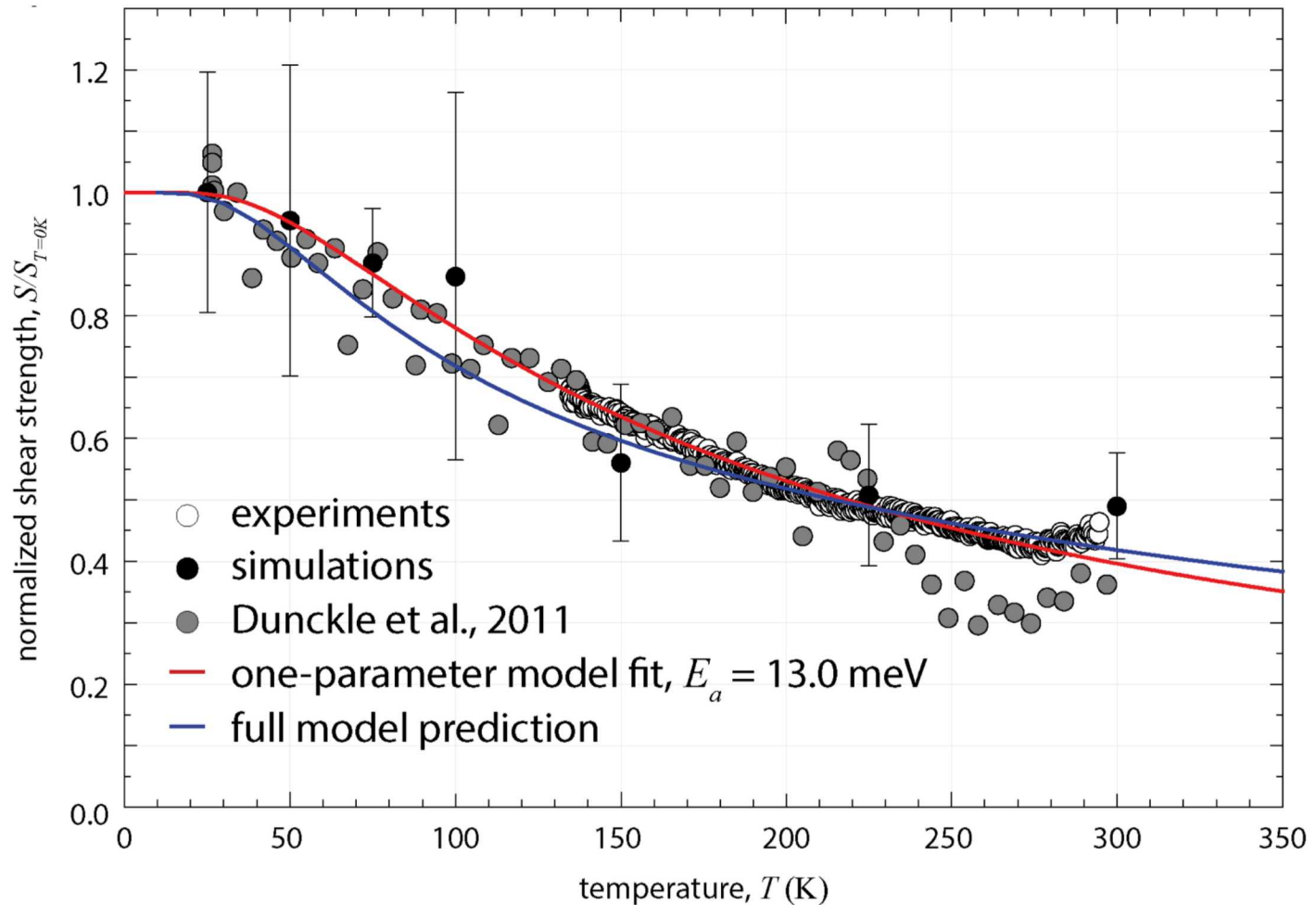
$$f_n = 1 - p_n$$

Total sliding probability & friction:

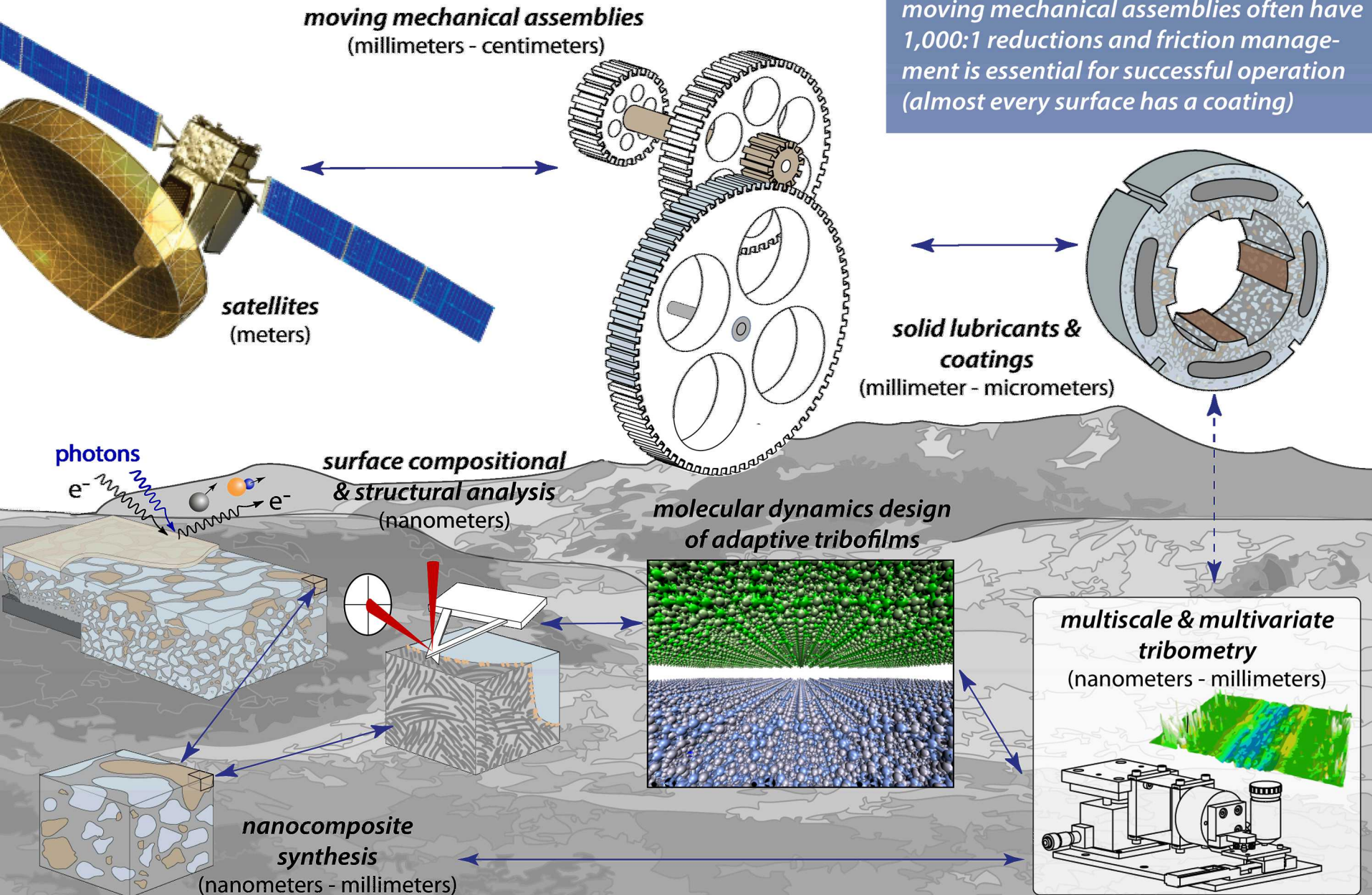
$$p_{slide} = p_r p_i + f_r p_c$$

$$f_{slide} = 1 - p_{slide} = 1 - (p_r p_i + f_r p_c)$$

$$f_{slide} = C_0 \left[ 1 - \exp\left(-\frac{E_i + E_r}{kT}\right) \right]$$



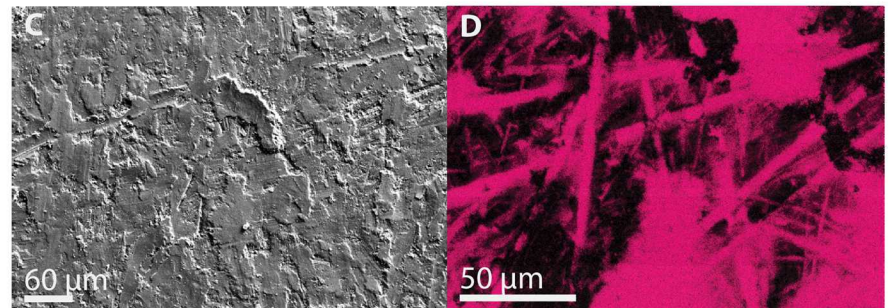
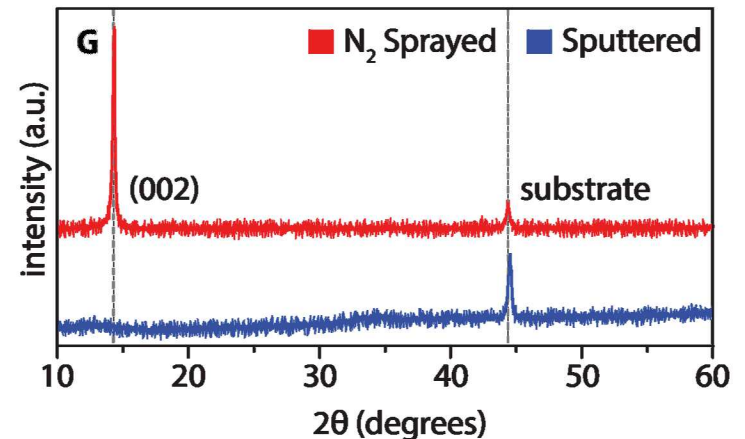
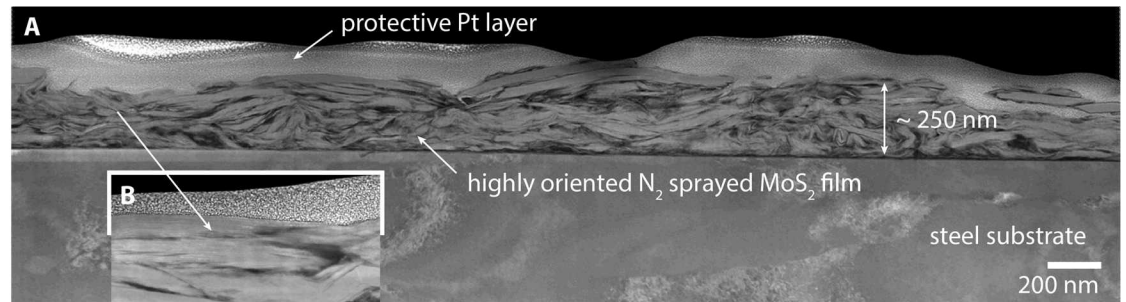
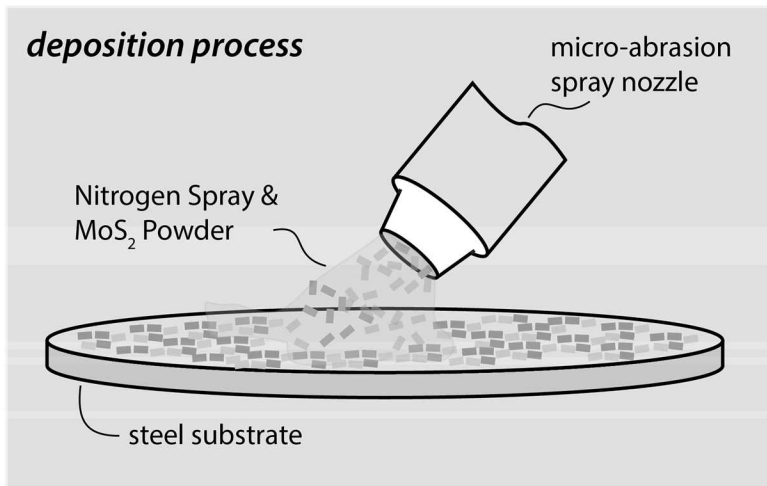
# Fundamental Studies & Applied Challenges

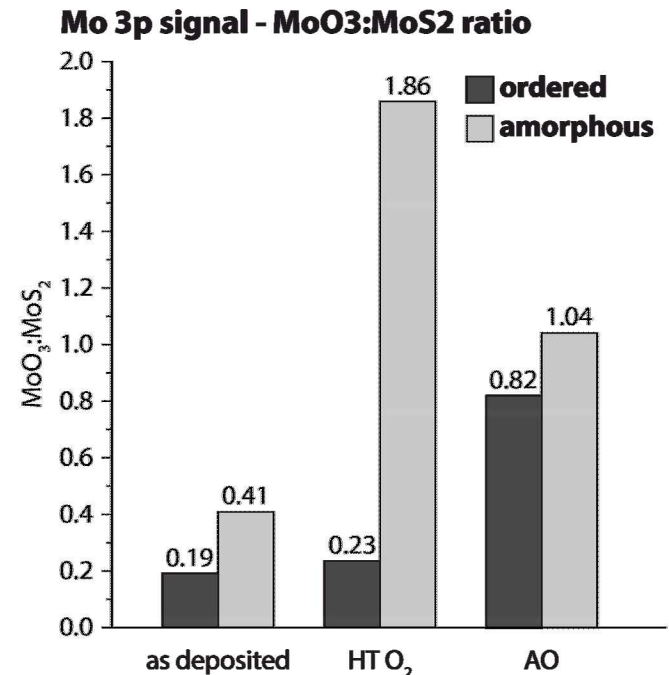
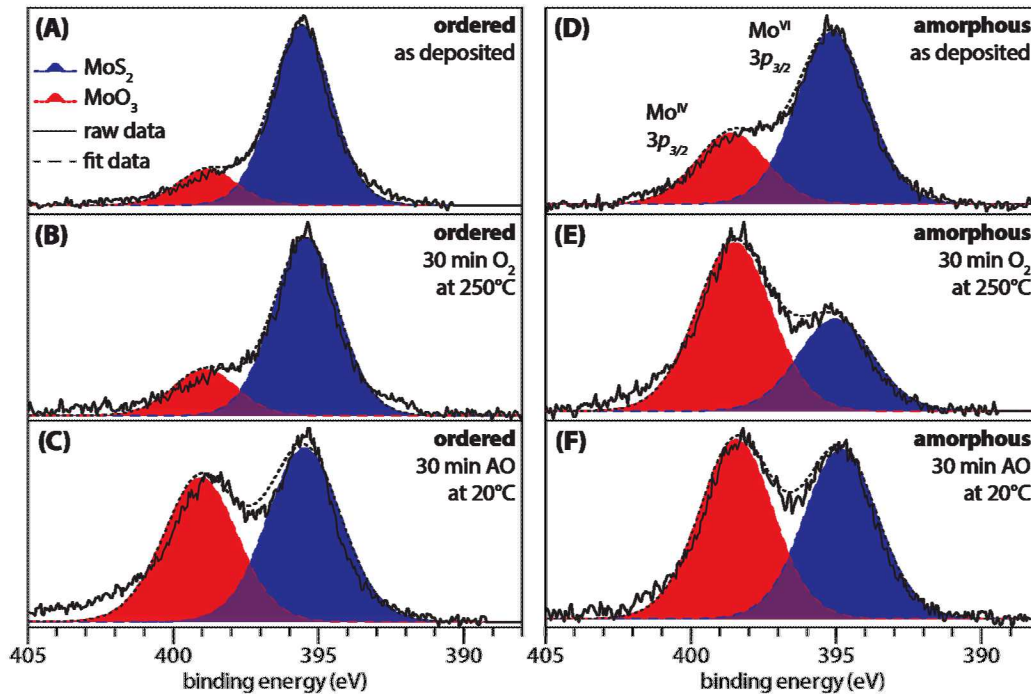




### Nitrogen Spray Deposited MoS<sub>2</sub>

- Deliver MoS<sub>2</sub> powder to surface in dry N<sub>2</sub> gas
- High kinetic energy imparted shears MoS<sub>2</sub> onto surface to produce a higher orientation of basal planes.
- Similar to burnishing, large continuous crystallites will form, reducing presence of surface defects

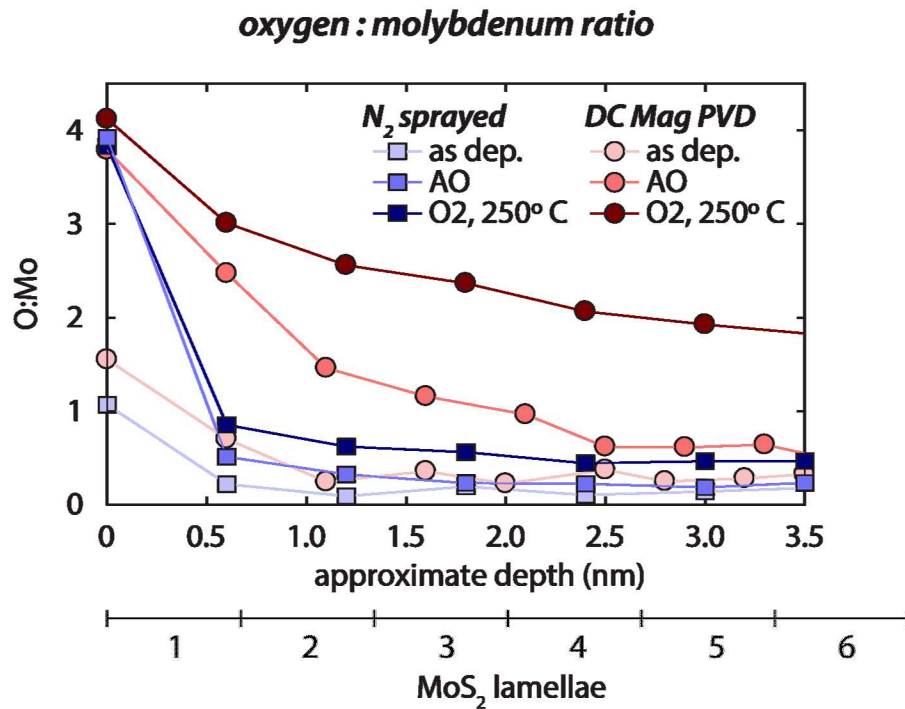




### Analysis

- (1) Higher MoO<sub>3</sub> concentration in as dep. PVD samples with higher ratio MoO<sub>3</sub>:MoS<sub>2</sub> (**0.41**) than sprayed (**0.19**)
- (2) Minor increase of MoO<sub>3</sub>:MoS<sub>2</sub> for ordered coatings after HT O<sub>2</sub> (**0.23**)
- (3) Significant increase in MoO<sub>3</sub>:MoS<sub>2</sub> for amorphous films (**1.86**) - likely due to greater oxygen diffusion
- (4) High MoO<sub>3</sub> concentration for AO in ordered (**0.82**) and amorphous coatings (**1.04**), yet limited to first layer for sprayed as shown in HS-LEIS
- (5) XPS results agree well and complement work done in HS-LEIS



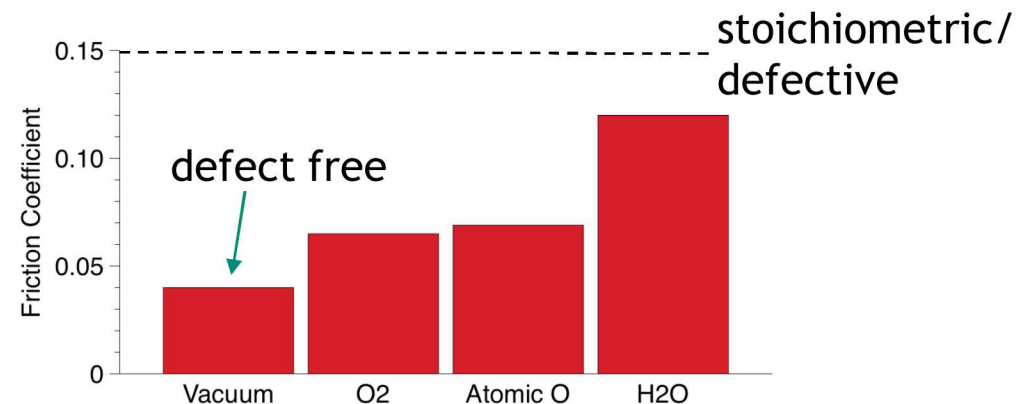
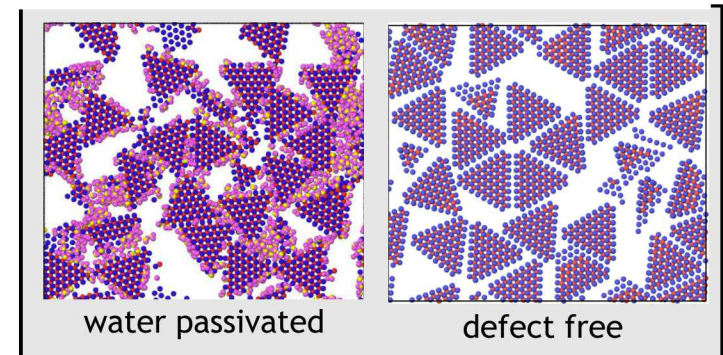
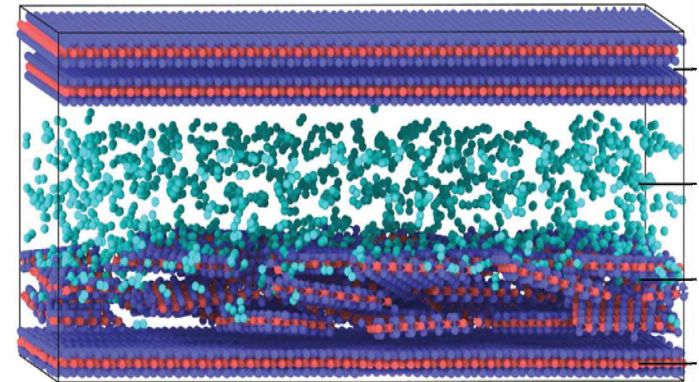


### Analysis

- (1) Oxygen content of the surface is the same for both coating types regardless of exposure
- (2) Oxygen persists through the depth of sputtered coatings exposed to either O<sub>2</sub> or AO
- (3) Oxygen is limited to the first atomic layer for sprayed coatings to either O<sub>2</sub> or AO

# Role of Water in Modifying Friction - Chemistry

- How does water actually modify friction?
- MD Simulations show water bonds to defect sites and aggregates, preventing formation of larger sheets
- More edge sites likely enhance adsorption as well, with more energetic and a higher number and potential sites
- Water can also increase drag between lamellae via polar bonding with water molecules [1]



# Role of Water in Modifying Friction – Flake Kinetics

- Increased friction may be explained by flake rotation mechanisms
- Relies upon model recently developed establishing a link between the probability of flake rotation as a function of temperature
- In this case, adsorption sites effectively pinning flake rotation, which then behaves in the same fashion as we described earlier...

